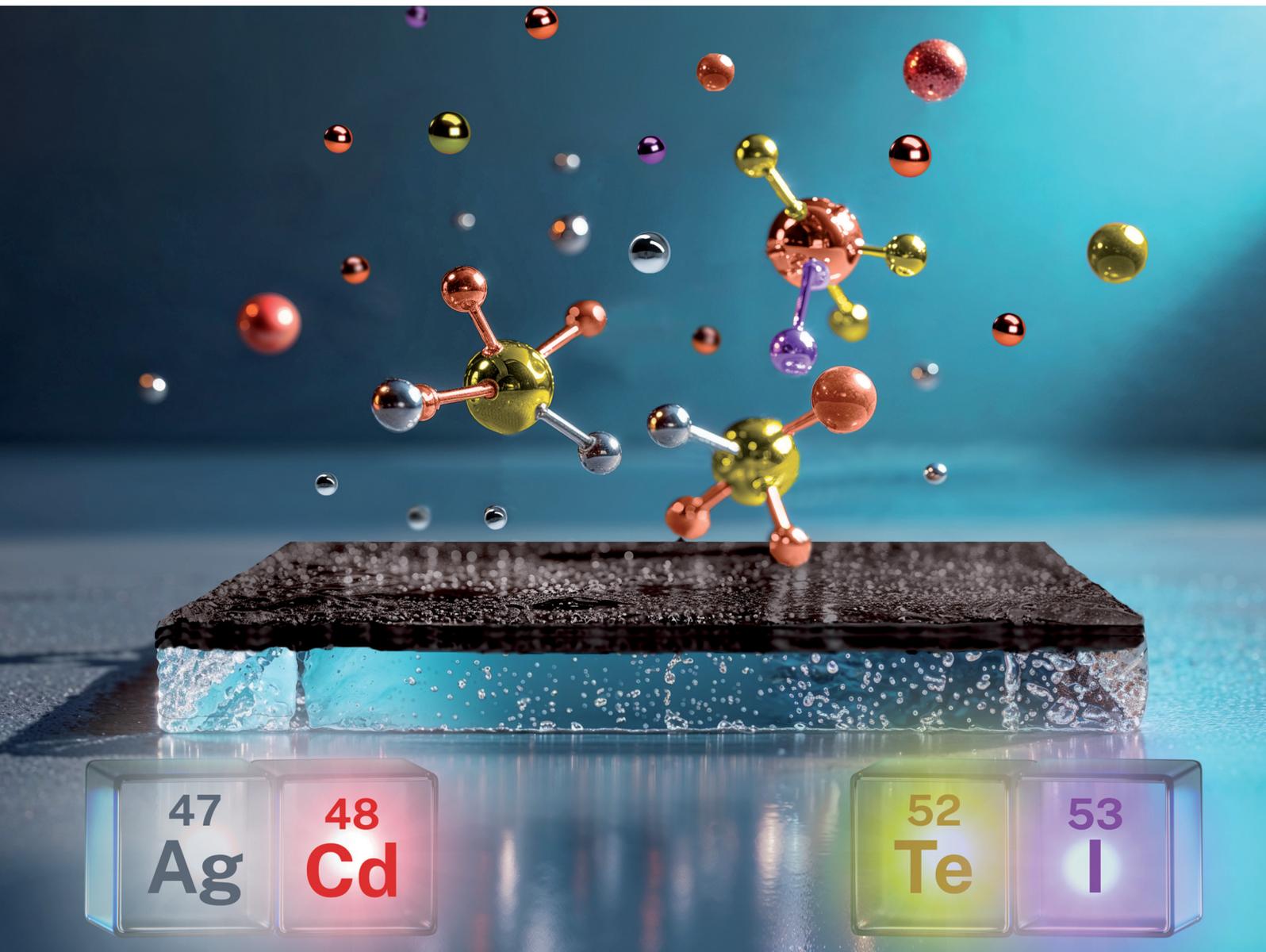


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Adjacent compensated codoping (alloying) of semiconductor films and its application in CdTe and CdS†

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Current optoelectronics technology is based on semiconductors that contain impurities with specific functionalities. Theoretical and experimental research on novel methods to overcome the difficulties in doping semiconductors continues to be an important and active field. In this work, the concept of adjacent compensated codoping is introduced and analyzed as an alternative method to tailor the properties of materials via the controlled incorporation of two types of impurities. This novel paradigm consists of selecting two dopants, both of which are adjacent to the host chemical element(s) in the periodic table. The selection is done in a compensated manner, wherein one is a p-type impurity and the other is an n-type impurity. Using this approach, while the structural and lattice dynamics properties of the host were marginally affected, its electrical and photoelectronic properties were significantly improved. The similarities in atomic masses, ionic radii and electronegativities between the host atoms and the adjacent codopants offered excellent solubilities. The application of this method to relevant semiconductors in photovoltaics, such as CdTe and CdS in the form of thin films, was also analyzed. Notably, the photoconductivities of CdTe and CdS were significantly enhanced at optimal concentrations of adjacent compensated codopants.

1. Introduction

The incorporation of impurities into semiconductors has been one of the cornerstones in the development of electronic and optoelectronic devices. Since the 1950s, experimental and theoretical efforts have been devoted to improve the properties of doped semiconductors. Such materials became useful for

various applications when impurities with specific functionalities could be incorporated in a controlled manner. The successful incorporation of impurities in semiconductors has been highly beneficial in the development and improvement of devices, while failure to do so, has hindered severely their progress. Major issues related to doping semiconductors have been analyzed in detail in some excellent reviews.^{1–4} Some of these issues are as follows:

(i) The selected impurity has limited solubility in the host. After a threshold concentration, the segregation of impurities may occur or secondary compounds may form. A concentration of 2–5 at% in semiconductor materials usually results in the clustering of dopants, significantly affecting the properties of materials.

(ii) The dopants produce deep levels in the host's bandgap in such a way that they cannot provide free carriers at temperatures used in performing devices.

(iii) Above a threshold concentration of free carriers, the crystalline host matrix reacts to further increments by forming oppositely charged native defects or complexes, compensating for any additional increase in the free charge density (e.g. DX centers^{5,6} or AX centers^{7,8}).

Examples of materials where doping issues have been engaged with various degrees of success in the past include: p-type doping of nitrides^{9,10} and wide-gap II–VI compounds;^{11,12} p-type doping of oxides for displays and transparent electronics;¹³ improved doping capabilities of active layers in solar cells,¹⁴ adequate doping of nanocrystals,^{15,16} two-dimensional¹⁷ and quantum materials.² Codoping, or dual doping, has been one of the alternative pathways investigated to modify the electronic properties of semiconductors and to solve some of the difficulties mentioned above. In some cases, dual doping has proven to be effective for improving solubility and addressing electronic deep-level issues. A historical roadmap of codoping can be found in ref. 18. Notably, the work by Katayama-Yoshida *et al.* is highlighted, wherein theoretical calculations were used to explore dual doping in wide bandgap materials, such as p-type GaN ($E_g = 3.4$ eV), p-type AlN ($E_g = 6.2$ eV), n-type diamond

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($E_g = 5.4$ eV)¹⁹ and p-type ZnO ($E_g = 3.2$ eV).²⁰ In the approach followed by Katayama-Yoshida *et al.*, impurity combinations of the type acceptor–donor–acceptor (A–D–A) and donor–acceptor–donor (D–A–D) were introduced in several hosts, yielding p- or n-type semiconductors, respectively. Codopants modify the crystal energetics owing to a change in the total energy caused by the interactions between the impurities and the host neighboring atoms. In some instances, this may lead to better solubility of dopants in the matrix, which can be accompanied by reductions in ionization energies (deep-level lifting) and by an overall redistribution of impurity-related electronic levels (with respect to those of single dopants) within the host bandgap. An example of this is the significant UV-to-IR bandgap renormalization from 3.2 to 1.8 eV of ZnO upon codoping with (Cu + Te).²¹

Doping II–VI semiconductors has become an active research field, particularly after failures to dope n- and p-type wide band gap materials, such as ZnTe ($E_g = 2.26$ eV) and ZnSe ($E_g = 2.7$ eV). It was found that semiconductors, such as sulphides and selenides of Zn and Cd, were resistant to p-type doping, while ZnTe could not be prepared with n-type conductivity. After decades of intensive work, a landmark was achieved when a p-type ZnSe was developed, which was appropriate for fabricating blue-emitting laser diodes.²² Recently, the effects of codoping in CdTe were investigated theoretically using first-principles hybrid functional calculations.²³ Another approach in dual doping is the so-called fully compensated cooping, in which the incorporation of n- and p-type impurities into a fully compensated manner produces electrical neutrality. In this case, its use does not enhance the electrical properties but can yield important effects on the electronic band structure¹⁸ when seeking to improve the performance of photocatalytic materials for hydrogen production in TiO₂.²⁴

Using the adjacent compensated codoping (ACC) concept presented here,²⁵ the crystalline structure and lattice vibrational properties of the host are modified to a low extent, while the electrical and photoelectronic properties were significantly improved, beyond the possibilities of single doping. The term adjacent compensated codopants implies introducing two different types of impurities selected as follows: the atomic number of one of them is larger by one (or two) unit(s) than one of the chemical elements forming the host, while the other impurity has an atomic number smaller by one (or two) unit(s) with respect to another chemical element of the host. Equivalently, ACC is the incorporation of n- and p-type dopants of chemical elements adjacent in the periodic table to those that form the host: one lighter (p-type) and one heavier (n-type). For example, for a binary compound AB formed with elements with atomic numbers Z_A and Z_B , under the ACC approach, AB can be codoped with combinations of impurities with atomic numbers $Z_A - 1$ and $Z_B + 1$, or with the pair $Z_A + 1$ and $Z_B - 1$ (hereafter the combinations of lighter/heavier $Z_A \pm 1$ and $Z_B \pm j$, $j = 1, 2$ codopants shall be designated as adjacent codopants). In the case of semiconductors, such as Si or Ge, the combinations of adjacent codopants refer to the elements on the right and the left to the single elements in the periodic table; for example, for germanium, the ACC impurities are Ga + As.

With adjacent compensated codopants,

(a) The strain in the host crystalline lattice is low. In general, the lattice expands owing to the incorporation of $Z_{A,B} + 1$ impurities, while it contracts upon the incorporation of $Z_{B,A} - 1$ impurities. This produces a partial, or nearly full, strain balance in the host lattice depending on the ionic radii of the involved adjacent codopants. These combinations substantially reduce dopant solubility issues owing to lattice strain.

(b) The use of n- and p-type impurities reduces the probability of forming compensating defects/complexes, which occur above a threshold concentration in semiconductors with a single type of impurity. It is expected that the presence of acceptors and donors in a certain region of a semiconductor reduces the charge imbalance generated when a single type of dopant is used, which in turn may improve the tunability of the Fermi level.

(c) Adjacent codopants may favor the formation of shallow levels (or bands). Since the atomic cores of adjacent codopants are similar to those of the host's atoms, the levels introduced in the gap by these impurities tend to be shallow. It should be pointed out, however, that this is a rule of thumb when a single type of dopant is used.²⁶

(d) The nature of the chemical bonds (covalent, polar covalent or ionic) in the host shall not change abruptly after the incorporation of adjacent codopants. The electronegativities of the atoms play an important role in the type of chemical bond that binds them. Using adjacent codopants implies that the electronegativity difference between codopants and the host atoms is the smallest possible.

(e) The lattice dynamics of the host are modified to a minimum with adjacent codopants. Since the atomic masses of the adjacent codopants are slightly different from the masses of the host (if adjacent codopants $Z \pm 1$ are employed, the mass differences are the least possible; if the codopants are $Z \pm 2$, the mass differences are the second least possible), the lattice vibrational properties of the host are slightly modified. Under this scheme, any trend toward phonon-related localization effects is poorly favoured (such as polaron localization).

Thus, in ACC, it is sought to maintain the minimum amount of disorder introduced in the host (*i.e.* low entropy changes owing to strain, local charge unbalance, chemical bonds, mass differences, and phonon frequencies) by the incorporation of two different types of impurities. This is graphically summarized in Fig. 1. The advantages and limitations of ACC are discussed below by presenting actual examples of applying ACC to technologically important semiconductor films, such as CdTe and CdS. Solubility issues were absent in these examples of the employed concentrations of adjacent codopants. Large free electron/hole densities were feasible, implying improved Fermi level tuning capabilities. In some instances, the photoconductivity and transient photo response reached large efficiencies. The results reported here indicate that adjacent compensated codoping can be an alternative paradigm for mitigating the issue of controlling the optoelectronic properties of semiconductors, where single doping faces difficulties. The results below show that in the case of ACC-CdTe, large n-type carrier densities and



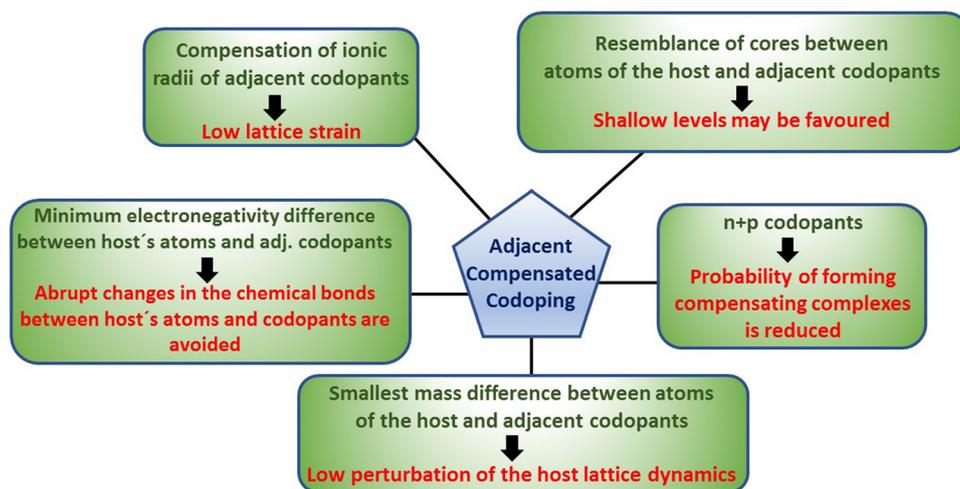


Fig. 1 Diagram describing the expected effects of applying the adjacent compensated codoping (ACC) concept on semiconductors. For example, in the case of a binary compound AB formed using chemical elements with atomic numbers Z_A and Z_B , ACC implies codoping with combinations of elements with atomic numbers $Z_A \pm i$ and $Z_B \pm j$, for $i, j = 1, 2$.

photoconductivity can be achieved. Additionally, the well-known photoconducting properties of CdS were enhanced. These properties are relevant to solar cell technology.

In the examples below, the amounts of codopants introduced in the hosts were in the range of atomic percentages, which produced semiconductors that could be classified as alloys rather than codoped semiconductors. In the case of transparent conducting oxides, such as ITO and FTO, the doping of indium oxide and tin oxide matrices is in the range of atomic percentages, falling rather into the category of alloys. However, the emphasis in this work is on the incorporation of two different dopants, for which the term codoping has been coined in the literature with a specific meaning. In this sense, the difference between alloys and doped semiconductors in this study is irrelevant.

2. Results and discussion

Given its relevance in the search for higher efficiencies in commercial solar cell technology, cadmium telluride was selected as the archetype to investigate the effects of applying the adjacent compensated codoping concept and its feasibility for controlling electrical and photoelectronic properties. A thorough investigation was carried out on two pairs of adjacent codopants in CdTe. Additionally, relevant results on using adjacent codopants in CdS are presented. All materials in this work were prepared in the form of thin films deposited on glass substrates by radio frequency sputtering.

2.1 Adjacent compensated codoping applied to cadmium telluride

CdTe is one of the most well-established materials as a photon absorber because of its chemical stability, high absorption coefficient ($\sim 10^4 \text{ cm}^{-1}$) and band gap (1.5 eV), which almost

coincides with the optimal value according to the Shockley-Queisser model.^{27,28} Efficient doping of CdTe presents some difficulties, especially when p-type conductivity is sought since free hole densities larger than 10^{15} cm^{-3} are difficult to obtain.²⁹ In addition, solubility problems have been reported through the formation of secondary phases or metallic segregation.^{30,31} Fig. 2 shows part of the periodic table, where two possible combinations of adjacent compensated codopants for CdTe are indicated. Moreover, Ag + I and In + Sb are the possible combinations of $Z \pm 1$ adjacent compensated codopants. The combination $Z \pm 2$ is not possible for CdTe because it involves Xe, a noble gas. For comparison and clarity purposes, the results for CdTe and CdTe:Ag films are presented first; then, a more detailed characterization of CdTe:(Ag + I) is provided where, strikingly, the secondary phases and Ag clusters observed in CdTe:Ag are avoided through the incorporation of (Ag + I) into CdTe.

2.1.1 Undoped CdTe. As a reference for the effect of adding adjacent codopants to CdTe, the properties of pristine sputtered films are presented. The crystalline quality of CdTe films is best when the substrate temperature is between 250 and 300 °C. Fig. 3 shows the structural, microstructural, optical and lattice dynamics properties of undoped CdTe films deposited with substrate temperatures (T_s) in this temperature range. The X-ray diffraction patterns, Fig. 3a, revealed the polycrystalline nature of the materials, oriented preferentially along the planes (111) of the cubic phase (PDF#00-015-0770). The presence of the hexagonal phase (PDF#00-019-0193) was confirmed through the appearance of the (103) peak at $2\theta \approx 43.1^\circ$. The broad features between 38° and 50° are due to a residual amorphous phase present in the samples, with the contributions of cubic and hexagonal peaks. It is noticed that, in general, the stable cubic phase grew with better crystallinity than its hexagonal counterpart, which presented broader peaks. With regard to the different substrate temperatures, the film grown at 250 °C had a strong preferential orientation of the cubic (111) planes. At 275 °C, the appearance of peaks related to



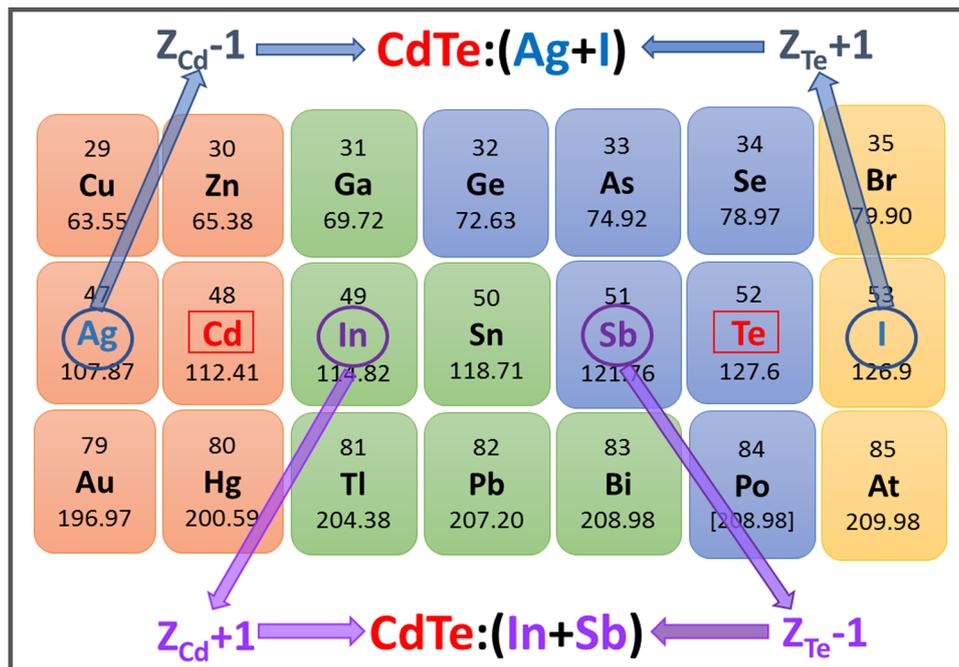


Fig. 2 Part of the periodic table, showing the ($Z \pm 1$) adjacent codopants for CdTe under the adjacent compensated codoping paradigm. CdTe:(Ag + I) and CdTe:(In + Sb) are the resulting materials.

the planes (220), (311), (400) and (331) reduced the preferential orientation (improved texture). The crystallinity of these films was best (*i.e.* lowest FWHM of the peaks) with respect to the films grown at other temperatures. At 300 °C, the crystalline quality decreased, the preferential orientation of plane (111) was maintained, and the characteristic peak (103) of the hexagonal peak broadened. It is noteworthy that since all films had a strong preferential orientation, the diffraction patterns in Fig. 3a are presented in a square root scale to produce the low intensity reflections. The SEM image in Fig. 3b corresponds to the surface of the film grown at 275 °C, showing a homogenous compact film with irregularly shaped grains in the submicron range (the scale bar corresponds to one micron). The surfaces of the films grown at 250 and 300 °C, not shown, presented similar characteristics. Fig. 3c shows steep transmittance edges for all films with an average transmission of around 70% in the non-absorbing region. The room temperature Raman spectra (Fig. 3d) showed up to the fifth overtone of the longitudinal optic (LO) mode of CdTe. The presence of overtones in the Raman spectra is associated with good crystalline quality.^{32,33} By considering the full width at half maximum (FWHM) of the diffraction peaks and the characteristics of the transmittance and Raman spectra, 275 °C was selected as the substrate temperature appropriate for the growth of CdTe films. This temperature was used for the growth of CdTe:Ag and for the codoped CdTe:(Ag + I) films.

2.1.2 CdTe:Ag. It has been found in the past that silver-doped CdTe presents solubility and thermal instability issues.^{33–35} For this work, films of CdTe:Ag were prepared at the previously selected substrate temperature of 275 °C for two silver concentrations: 0.5 and 3 at%. Fig. 4a presents the X-ray diffraction patterns of the films, where it is observed that all the

peaks of the sample with 0.5 at% Ag can be identified with the diffraction of cubic CdTe powder (PDF#00-015-0770), that is, Ag stabilizes the cubic phase with preferential growth parallel to plane (111). No peaks of the ubiquitous metastable hexagonal wurtzite phase were detected. When the silver concentration was 3 at%, the preferential orientation was reduced while maintaining the cubic zinc blende phase as the only crystalline phase present. In addition, in this film, diffractions from metallic Ag (PDF#00-004-0783) and hessite Ag₂Te (PDF#00-034-0142) aggregates were present in the pattern, demonstrating that the solubility limit of Ag in CdTe is below 3 at%. By comparing the SEM images of Fig. 4b and 3b, it is clear that silver promotes the crystallization of CdTe. The crystallites of CdTe:Ag in Fig. 4b reached sizes on the order of one micron. This effect of Ag on the growth dynamics of CdTe has been observed previously in nanoparticles and films.^{36,37} The influence of the large absorption coefficient of Ag₂Te^{38,39} is demonstrated in the transmittance spectra in Fig. 4c since it dominates the transmittance spectrum of the film with 3 at% Ag. Silver telluride is a low band gap material with values of 0.025 and 0.67 eV for the monoclinic and cubic body-centered crystalline phases, respectively.⁴⁰ Even for 0.5 at% Ag, the presence of Ag₂Te (very likely in the form of nanoparticles since the corresponding X-ray diffraction pattern did not show any related peaks) was revealed through the reduction of the average transmittance in the transparent region ($\lambda > 815$ nm) from ~70% for CdTe to ~45% in CdTe:Ag-0.5%. However, the Raman spectra of the films did not show noticeable differences with respect to pristine CdTe. The LO mode and five harmonics were observable, with no features related to Ag₂Te. This was because the Raman spectrum of Ag₂Te is weak⁴¹ and overshadowed by the signal of CdTe.



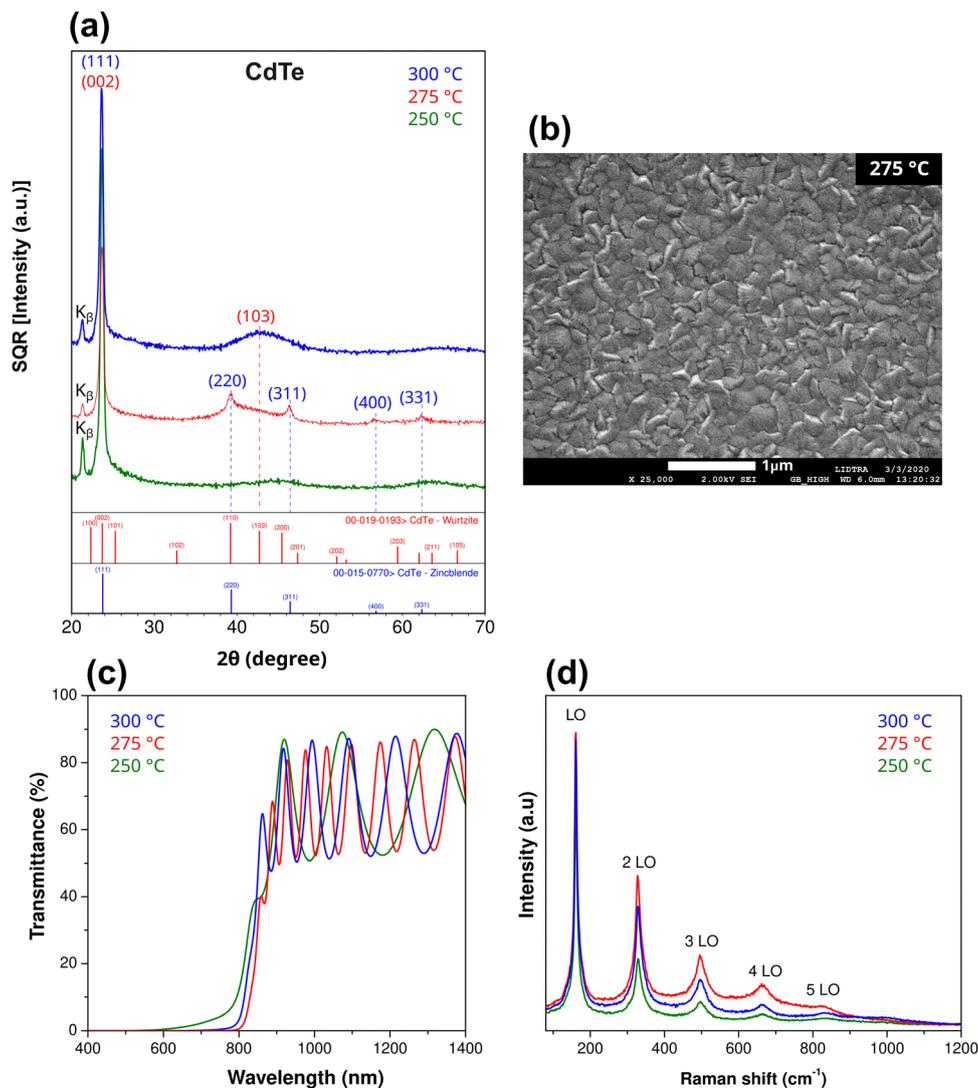


Fig. 3 Structural, morphological, optical and lattice vibrational properties of undoped CdTe films grown at substrate temperatures in the 250–300 °C range. (a) X-ray diffraction patterns showing preferential growth of the cubic (111)/hexagonal (002) planes. To enhance the low intensity peaks, the square root of the intensity was plotted. The broad features between 38° and 50° correspond to convoluted cubic and hexagonal peaks with some amorphous backgrounds. (b) SEM image showing the surface morphology of the film grown at 275 °C. The white bar corresponds to 1 μm. (c) Optical transmittance in the Vis-NIR range showing an abrupt transmission edge for all the films. The oscillations are due to multiple reflections and interferences from the air/film and film/substrate interfaces. (d) Room temperature Raman scattering spectra showing the longitudinal optic mode (LO) of CdTe up to the fifth overtone.

2.1.3 CdTe:(Ag + I). The samples were grown from composite targets fabricated with CdTe and AgI powders. The concentrations of AgI in the sputtering targets were 0.5, 1.0, 3.0, 4.0, 5.0, 6.0 and 7.0 at%. The thicknesses of the films are presented in Table S1 (ESI[†]). The X-ray diffraction patterns of the films are presented in Fig. 5a. All peaks correspond to CdTe with cubic (PDF#00-015-0770) and hexagonal (PDF#00-019-0193) symmetries. Rietveld refinement of the diffractograms indicated that a cubic to hexagonal crystalline phase transition occurred as the Ag + I concentration increased. Accordingly, the preferential orientation changed from cubic (111) to hexagonal (002). When the codopant concentration reached 7 at%, only well-defined peaks of the hexagonal wurtzite phase were detected and preferentially orientated parallel to the (002) planes. However, this reflection made a small contribution to the cubic (111) phase.

The other two peaks in the pattern, (103) and (105), belong to the family of hexagonal planes {10 l }. The small feature at ~21° was due to the K_{β} line of the X-ray beam. Contrary to what was observed in the diffractograms of the CdTe:Ag films, aggregates of Ag or Ag₂Te were not detected, as illustrated in Fig. 4a. Thus, iodine as the adjacent codopant partner of silver precluded the formation of secondary phases. The ionic radii of Cd²⁺ and Ag¹⁺ for coordination four are 78 and 100 pm, respectively.⁴² The ionic radii of four-fold coordinated Te²⁻ and I¹⁻ are not known although their values should not be significantly different from those reported for coordination six, which are 221 and 220 pm, respectively. It is noteworthy that in the case of the O²⁻ ion, its radius for coordination four is only 2 pm smaller than that for coordination six. The lattice constants of the cubic and hexagonal phases were obtained through Rietveld refinements of the



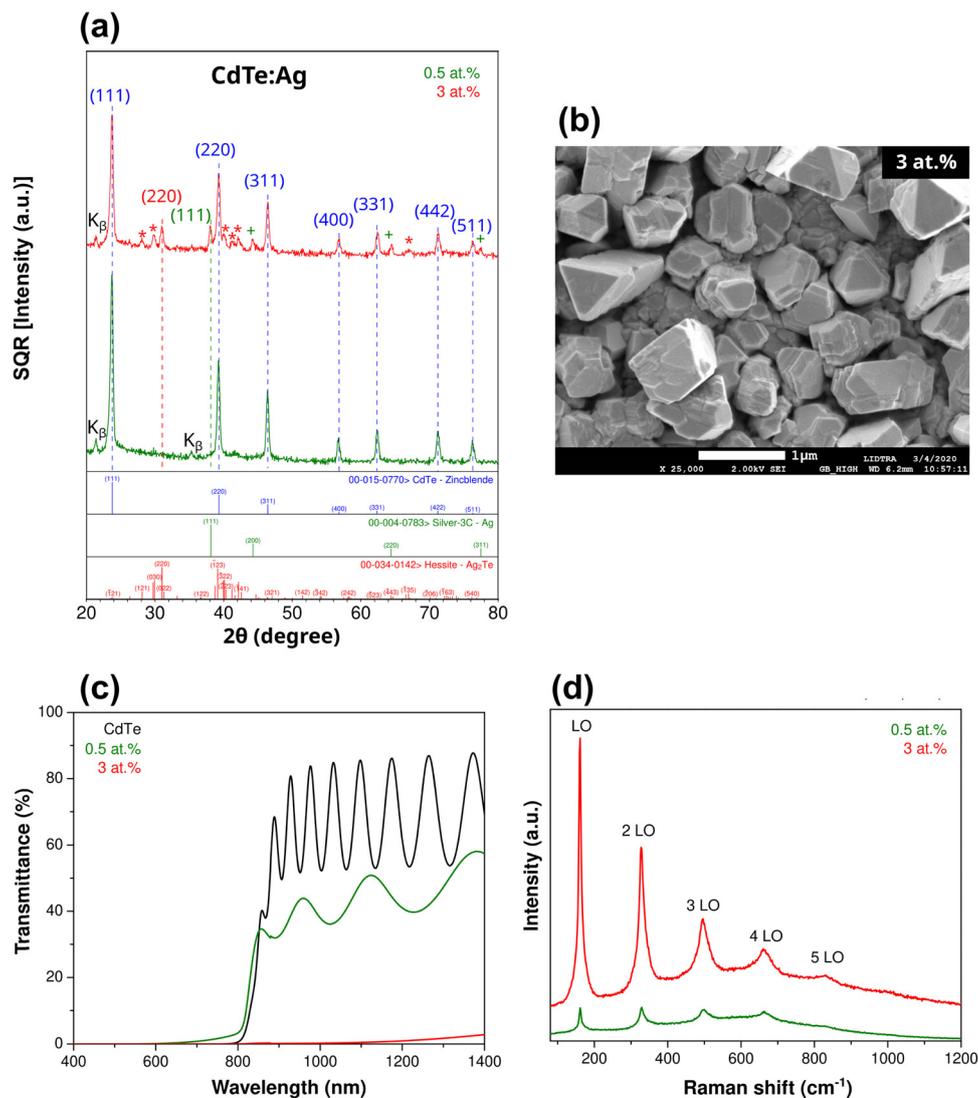


Fig. 4 (a) X-ray diffraction patterns of CdTe:Ag films for silver concentrations of 0.5 and 3 at%. With 3 at%, the solubility limit of Ag in CdTe was surpassed, producing aggregates of Ag and Ag₂Te. (b) SEM surface micrograph of the sample with 3 at% Ag, where crystallites as large as one micron were observed (scale bar = 1 micron). (c) Vis-NIR transmittance spectra showing important differences produced by the large absorption coefficient of Ag₂Te, which dominates the spectrum of the film with 3 at% Ag. (d) LO mode of CdTe and its overtones observable in the Raman spectra. Raman signal of the Ag₂Te aggregates is weak and overshadowed by that of CdTe.

diffraction patterns using Fullprof.⁴³ The small differences in ionic radii between the codopants and the atoms of the host produced minor changes in the lattice constants of the cubic and hexagonal structures of the CdTe host. According to the data shown in Fig. 5b, the largest difference in the lattice parameter of the cubic phase was 0.0045 Å, while for the hexagonal phase, the largest difference in the *c/a* ratio was 0.056 Å. The optical transmittance of the CdTe:(Ag + I) films presented characteristics similar to those of CdTe, as shown in Fig. 5c and Fig. S1 (ESI[†]). The room temperature band gap (E_g) was determined from the transmittance spectra using Tauc's plots. The band gap varied from 1.42 to 1.46 eV, while for the CdTe film, E_g was 1.5 eV.

Nonetheless, the influence of the adjacent codopants on the growth habits of the films was noticeable. Fig. 5d–g and Fig. S2 (ESI[†]) (different magnifications) present the SEM images of the

surfaces of the films grown from targets with 4–7 at% AgI. The microstructure changed with respect to undoped CdTe (Fig. 3b) upon increasing the concentration of the codopants. It is pointed out that the 5 at% AgI film showed the largest and best-defined grains, which was consistent with its large photoconductivity, as described below.

Photoluminescence (PL) is a useful technique for studying the electronic properties of semiconductors. In particular, PL has been applied to the study of diverse types of defects, including impurities and complexes in CdTe.^{44–47} Fig. 6a shows the PL spectra of the films obtained at 80 K. All samples were excited using the same laser power density and integration times. The sample with 6 at% AgI presented the most intense signal. The spectrum of CdTe showed a broad band centered at 1.43 eV with two satellite emissions on the sides (Fig. 6b). This



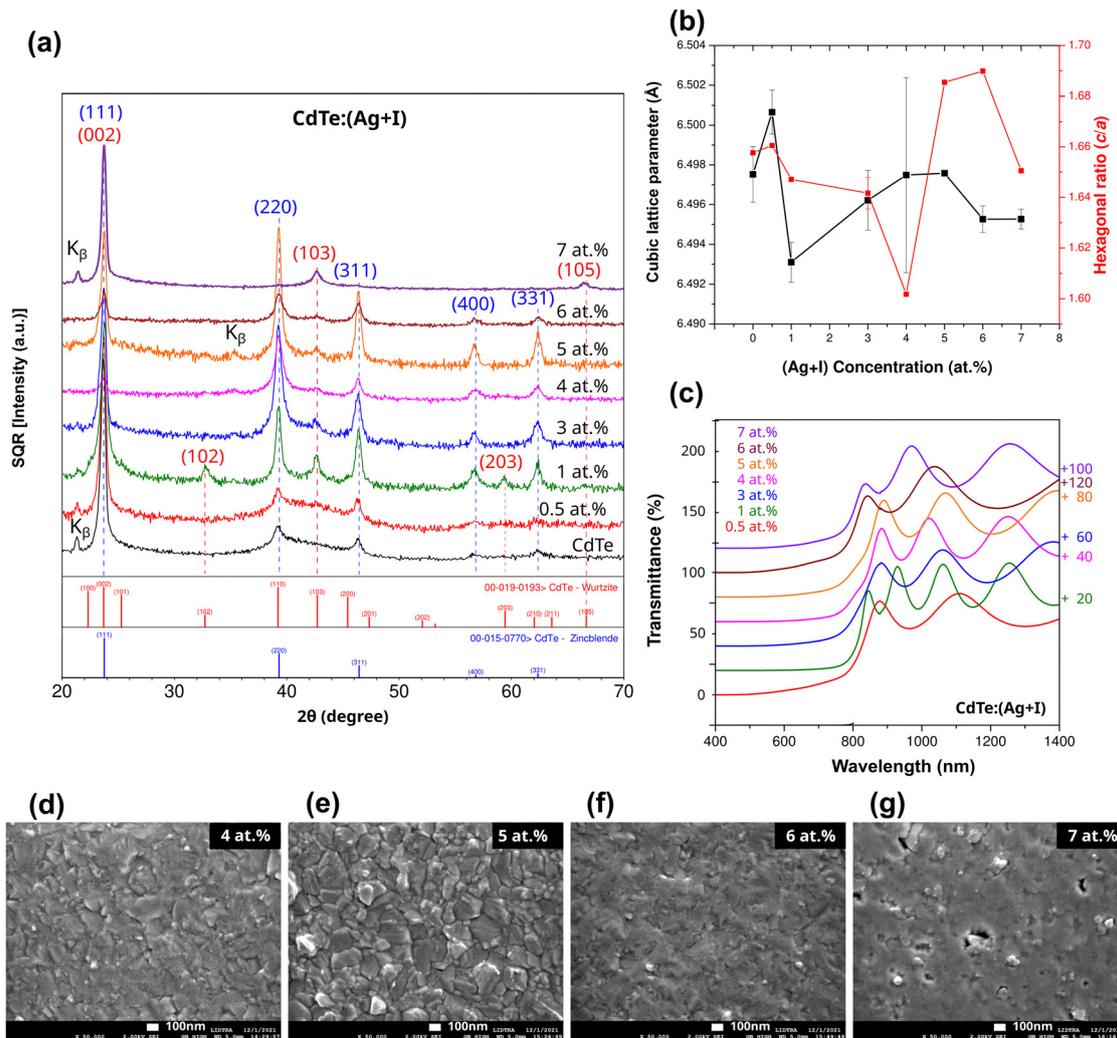


Fig. 5 (a) X-ray diffraction patterns of the CdTe:(Ag + I) films, with the indicated concentrations of adjacent codopants. Secondary phases were not detected as in the case of CdTe:Ag. The panes at the bottom correspond to the powder diffraction data for the cubic (PDF#00-015-0770) and hexagonal (PDF#00-019-0193) phases. (b) Lattice parameter variation in the cubic (a) and hexagonal (c/a) ratio as a function of the adjacent codopant concentrations. The parameters were obtained through Rietveld refinements of the diffractograms. (c) Vis-NIR transmittance of the films; the spectra were displaced vertically by the indicated quantities for clarity. (d)–(g) SEM images of the films with 4, 5, 6 and 7 at.% AgI in the target. The white scale bar corresponds to 100 nm.

spectrum was similar to the one observed in sputtered films grown at 270 °C (nearly the same substrate temperature used in this work, 275 °C) reported by Roland *et al.*, who associated the PL bands with structural defects.⁴⁵ The energies of the defect levels in the CdTe films are shown in the deconvoluted spectrum in Fig. 6b. The highest energy band occurred at 1.48 eV. The band gap of CdTe at 80 K is reported experimentally at 1.595 eV.⁴⁸ The excitonic transition in Fig. 6b was absent even though its binding energy (11.7 meV⁴⁹) was above the thermal energy during the measurements ($k_B T = 6.89$ meV). This indicates that exciton recombination can be mediated, or inhibited, by defect levels. Based on Roland *et al.*'s work, a CdCl₂ treatment was necessary to produce a weak feature identified as excitonic. Except for the film with 6 at.%, the spectra of the CdTe:(Ag + I) films shifted to higher energies with common maxima at 1.51 eV. The emissions of the codoped

films were broad and asymmetric, with different relative intensities. The asymmetry was the result of three different emissions, as shown in the deconvoluted spectrum of the 5 at.% sample in Fig. 6c. It is interesting to note that, even though in the literature there are no reports on the PL of CdTe:(Ag + I), the emissions at 1.45, 1.47 and 1.51 eV have their counterparts in CdTe doped with chlorine,⁵⁰ an isovalent element with iodine. In this case, the band at 1.45 eV was associated with A centers, which are complexes formed by Cd vacancies and Cl_{Te} donors. The band at 1.47 eV was identified as D–A recombinations.⁵⁰ In another work, the same band was linked to structural extended defects.⁴⁵ Although close in energy to the double-peak (DP) band at 1.55 eV,⁴⁵ the origin of the band at 1.51 eV (80 K) has not been identified. Previous studies in CdTe:I films showed that the PL intensity can be 10–100 times stronger than in bulk CdTe.^{47,51} Some enhancement with respect to CdTe (~5 fold) was observed



for the sample with 6 at% (Ag + I), Fig. 6a. In the case of silver, it is a shallow impurity in CdTe for which near-edge emissions at 1.588 eV were observed at 1.8 K.⁵² Considering that the band gap of CdTe at that temperature is 1.606 eV, the ionization energy of the Ag level is ~ 18 meV, which makes it unlikely that the 1.51 eV emission in CdTe:(Ag + I) is related to silver since the activation energy is $E_g^{80K} - 1.51 \text{ eV} = 85 \text{ meV}$. The similarities between the PL spectra of CdTe:(Ag + I)-5 at% and CdTe:Cl suggest analogous defect-passivation effects produced by the isovalent halide iodine (in CdTe:(Ag + I)) and chlorine (in CdTe:Cl), which in turn produce comparable defect-related radiative transitions.

The electrical properties of CdTe were significantly enhanced upon the incorporation of the adjacent codopants Ag + I. The results of the room temperature Hall effect measurements for concentrations between 4 and 7 at% are presented in Fig. 7a. The films with concentrations below 4 at% had resistivities larger than the equipment limit ($\sim 10^7 \Omega \text{ cm}$). The resistivity of the codoped CdTe:(Ag + I) films dropped monotonically with the (Ag + I) concentration. The resistivity of the film with 7 at% was $36 \Omega \text{ cm}$, 6 orders of magnitude lower than that of intrinsic CdTe, whose resistivity is typically $\sim 10^7 \Omega \text{ cm}$. The mobility, however, decreased, obtaining values between 6.5 and $0.2 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ as the concentration of codopants changed from 4 to 7 at%.

As opposed to undoped CdTe, the codoped films presented n-type characteristics, with free electron densities varying from 10^{15} to $\sim 1 \times 10^{18} \text{ cm}^{-3}$.

The compound AgI was used in the target as a source of silver (acceptor) and iodine (donor). These two elements were thus present in the target in a one-to-one ratio. However, the films were not highly resistant when full compensation occurred. Two observations can be made in this regard. First, the concentration of adjacent codopants in the target was not replicated in the films. This is a consequence of the different properties of the compounds, such as sputtering yield, sticking coefficients, and the natural off-stoichiometric trend of each compound. For example, CdTe tends to be Cd deficient owing to the large vapor pressure of this element. Fig. 6d shows the chemical composition of the CdTe:(Ag + I) films obtained by WDS, where it is noticed that the $[\text{Te}]/[\text{Cd}]$ and $[\text{Ag}]/[\text{I}]$ ratios are larger than one. Since the concentrations of adjacent codopants are of the order of atomic percent, it is expected that the impurity levels form sub-bands rather than discrete spaced apart levels. Second, the donor- and acceptor-like sub-bands, in general, present several asymmetries, as depicted in Fig. 7b. In particular, these are characterized by different ionization energies E_n and E_p , different widths δE_n and δE_p , and different densities of states D_n and D_p since the inter-level

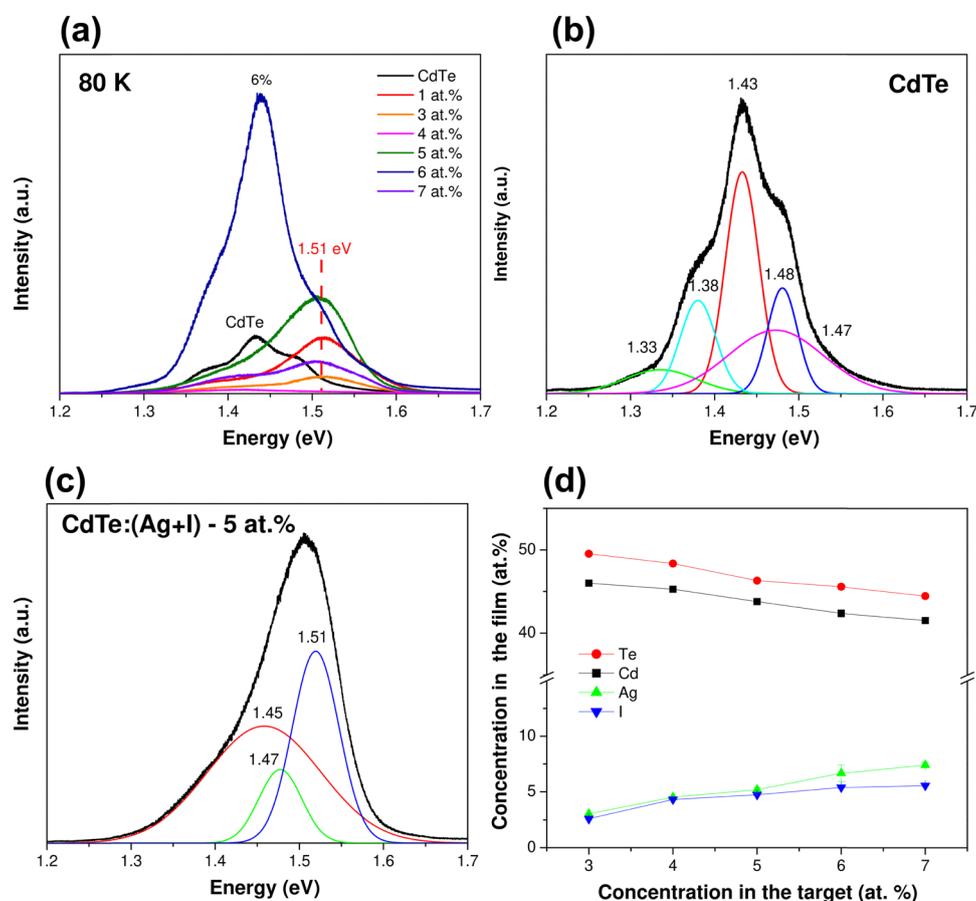


Fig. 6 (a) Photoluminescence spectra of CdTe and CdTe:(Ag + I) films measured at 80 K using a 785 nm laser as the excitation source. All samples were excited using the same laser power density and integration times. (b) Deconvolution of the PL spectrum of the undoped CdTe and (c) the film with 5 at% AgI. (d) Chemical composition of the CdTe:(Ag + I) films obtained using WDS as a function of the concentration of AgI in the sputtering target.



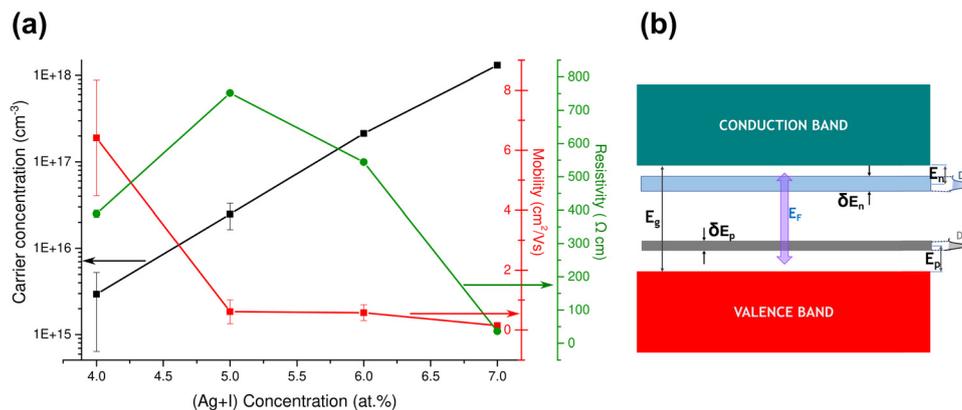


Fig. 7 (a) Values of the free electron concentration, mobility and resistivity obtained at room temperature Hall effect of the n-type CdTe:(Ag + I) films as a function of the concentrations of codopants. (b) Generic energy diagram of a semiconductor with adjacent compensated codopants illustrating, for example, the formation of donor- and acceptor-like sub-bands with ionization energies E_n and E_p , widths δE_n and δE_p , and densities of states D_n and D_p . The Gaussian-like shape of the densities of states was arbitrary to depict a possible non-uniform inter level spacing. The position of the Fermi level (violet arrow) is a function of the concentration of adjacent codopants, the position and characteristics of the donor/acceptor sub-bands and their occupancy.

separation in the sub-bands is not necessarily the same (the surroundings of each impurity in the lattice is different). The characteristics of the donor and acceptor sub-bands (E_i , δE_i and D_i) and their electronic occupation determine the type and magnitude of the conductivity. Another factor that should be considered is the substitutional or interstitial incorporation of the adjacent codopants in the CdTe lattice. Their location in the lattice can generate p- (Ag_{Cd} , I_i , and V_{Cd}) or n-type (Ag_i , I_{Te} , and V_{Te}) conductivity. However, it is expected that the similarities between the adjacent codopants and the atoms of the host favor substitutional incorporations (Ag_{Cd} and I_{Te}). Besides, the donor and acceptor sub-bands with separate impurity levels are not ruled out, which could be the result of codopants at non-substitutional sites, forming complexes with defects or with the host's atoms.

Photoconductivity (PC) was one of the most improved properties of CdTe when the ACC approach was applied. The photoconductivity of a semiconductor is an important property since it can be applied in various optoelectronic devices, such as photo detectors, sensors and solar cells. The enhancement of the electrical conductivity in a semiconductor under illumination is due to the photo-generation of electron-hole pairs, which produce electrical current when an electric field is applied. It is shown below that ACC transformed the sputtered CdTe films from having negligible photoconducting activity to a photo current three orders of magnitude larger than the current in the dark. PC was investigated under two conditions: steady state and transient (on-off) illumination.

In a semiconductor characterized by electron and hole concentrations at equilibrium n_0 and p_0 and drift mobilities μ_n and μ_p , under illumination, the increase in conductivity is given by⁵³

$$\sigma_{\text{ph}} = \Delta\sigma = \sigma_{\text{light}} - \sigma_{\text{dark}} = e(\mu_n\Delta n + \mu_p\Delta p),$$

where $\Delta n = n - n_0$ and $\Delta p = p - p_0$ ($\Delta n = \Delta p$) are the excess free electron and hole densities upon illumination. In the equation above, it is assumed that the carrier mobilities do not change with light. Photosensitivity is defined as the ratio $r = I_L/I_D$, where

I_L is the photocurrent and I_D is the current in the dark.⁵⁴ The basic processes controlling the photocurrent are the generation of free electrons and holes, the transport of the free carriers across the material under the influence of an applied electric field, the collection of carriers at the contacts, and the detrimental electron-hole recombination.⁵⁵ Fig. 8a shows the photocurrent (red line) and the current in the dark (black line) of a CdTe film when a voltage between -10 and $+10$ V was applied. The current measured in both cases was noisy and below nA, that is, a negligible photo response. However, all films of CdTe:(Ag + I) had photo sensitivities of above one, as shown in Fig. 8b. Films with 5 at% AgI exhibited the highest photosensitivity ($r = 5.15 \times 10^3$). Iodine and silver acted as efficient extrinsic activators⁵³ in CdTe. This could also be interpreted as iodine introducing additional defect passivation, such as that observed in chlorine treatments, possibly as a result of iodine's isovalency with chlorine. Fig. 8c shows the current for this sample with illumination and in the dark for voltages between -5 and $+5$ V in the linear and semi-log graphs. The ohmic contacts formed with the copper telluride (CuTe, vulcanite) contacts can be seen on the left-hand side graph. In previous work, n-type doping in polycrystalline CdTe thin films was achieved, but when a chloride treatment was applied to passivate the film, the n-type conductivity was lost.⁵⁶ In contrast, this work demonstrated both high n-type conductivity and improved carrier lifetime over undoped CdTe, avoiding the issues encountered previously.

Transient photoconductivity (TPC) is a property useful for analyzing the response of a semiconductor to light on/off cycles. The TPC data for films with 4–6 at% AgI are shown in Fig. 8d. The photocurrent presented sharp on/off steps, with different values of the saturation current (light-on plateaus) and the currents in the dark. The largest on/off current contrast was for the film with 5 at% AgI, as expected from the photosensitivity data in Fig. 8b. The largest photocurrents were ~ 0.145 μA for the films with 5 and 6 at%. The electrical contacts were stable during the on/off cycles, allowing for the efficient transfer of the carriers. A slight decrease in the



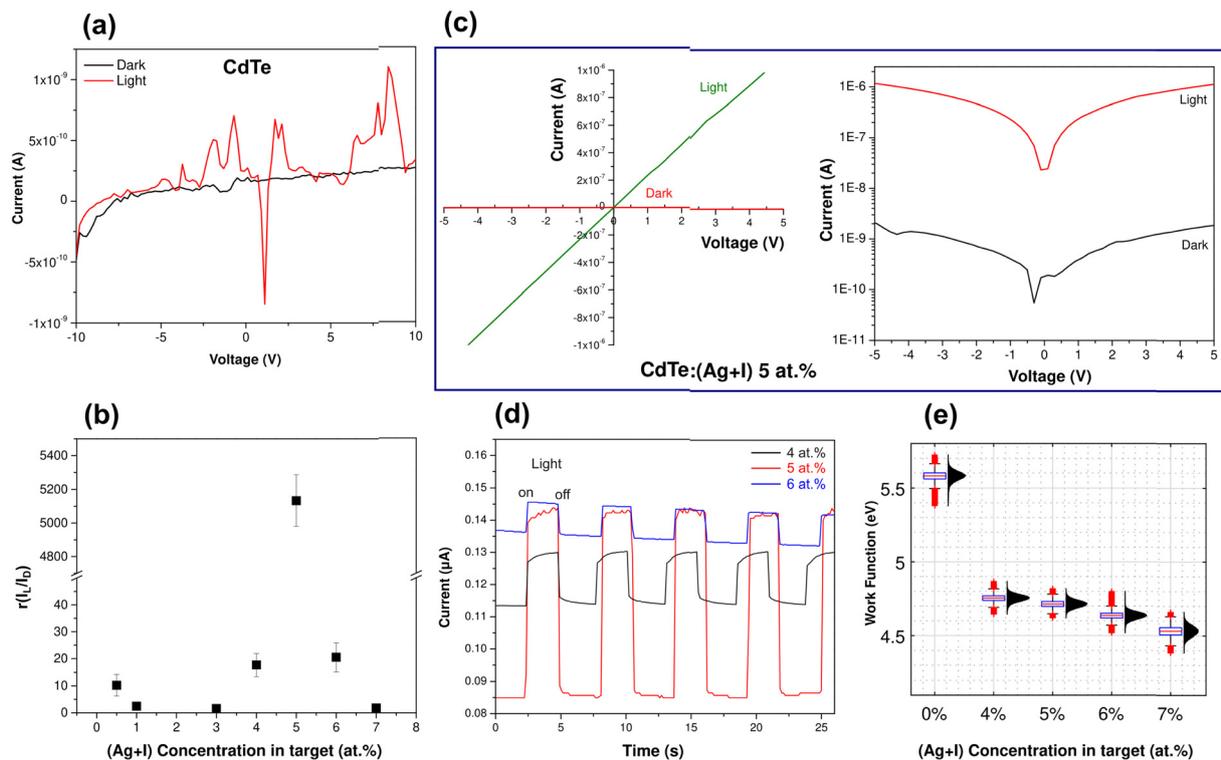


Fig. 8 (a) Current–voltage characteristics of a CdTe-sputtered film under illumination and in the dark. In both cases, the current was at the level of noise ($< nA$). (b) Photosensitivity ($r = I_{\text{Light}}/I_{\text{Dark}}$) of the CdTe:(Ag + I) films as a function of the concentration of AgI in the target. The largest value of r (5.15×10^3) was obtained for the film with 5 at%. (c) Comparison of the photocurrent in the light and in the dark as a function of applied voltage for the film with 5 at% AgI in linear and semi logarithmic graphs. The photocurrent was three orders of magnitude larger than that in the dark. The ohmic characteristics of the CuTe contacts are appreciated in the linear graph. (d) Transient photoconductivity of the films with 4–6 at% AgI for an applied voltage of 1 V. (e) Work function of the CdTe and CdTe:(Ag + I) films obtained using Kelvin probe force microscopy for the indicated concentrations of AgI in the sputtering target (scanned surface: $1 \times 8 \mu\text{m}^2$).

photocurrent during the TPC cycles with time was observed in the sample with 6 at% AgI (Fig. 8d). This reduction has been ascribed to a drop in the free electron density in other II–VI semiconductors, such as CdS and CdSe.⁵⁷ Importantly, the incorporation of the adjacent codopants Ag + I reduced the work function (W) from 5.6 eV for undoped CdTe to values between 4.52 and 4.75 eV, as shown in Fig. 8e. Thus, the Fermi level was a function of the concentration of Ag + I. This result is relevant for applications in which obtaining ohmic contact with CdTe has been challenging because of its large work function. Several approaches have been undertaken in photovoltaic devices to overcome this problem, sometimes resulting in complicated structures or technical difficulties. Considering that the work function of CuTe (the material of the contacts in the PC experiments) is 4.85 eV⁵⁸ and from the values in Fig. 8e, the work function difference (ΔW) at the CuTe/CdTe junction is 0.75 eV, which contrasts with $\Delta W = 0.15$ eV for the CuTe/CdTe:(Ag + I)-5% interface, an important 0.6 eV reduction at the interfacial barrier.

2.1.4 CdTe:(In + Sb). Another pair of adjacent codopants for CdTe is indium and antimony (Fig. 2). Cadmium telluride films and crystals doped separately with indium or antimony have been the subject of extensive research in the past.^{59–63} When substitutional, In acts as an n-type impurity, while Sb

acts as a p-type impurity. In this work, films of CdTe:(In + Sb) were prepared using indium antimonide (InSb) as the source of the codopants. This compound crystallizes the same cubic crystalline structure as CdTe (zinc blende type). Sputtering targets were prepared with 4.0, 5.0, 6.0 and 7.0 at% InSb. Fig. 9a shows the X-ray diffraction patterns of the films. The cubic phase of CdTe was favored over its hexagonal counterpart when the codopant concentration was 4 at%. For concentrations ≥ 5 at%, the cubic phase was stabilized. The preferential orientation changed from the cubic (111) planes in undoped CdTe to planes with orientation (220) as the concentration of In + Sb increased. The lattice parameters of the films are shown in Table S2 (ESI[†]), in addition to the values of strain ($S = \Delta a/a_0$), whose largest value was 0.14%. It is also noted that precipitates of In_2Te_3 or Sb_2Te_3 were not observed in the diffraction patterns, indicating the good solubility of In + Sb in CdTe. The lattice constant of CdTe (0.6481 nm) matches that of InSb (0.6480 nm); thus, their X-ray diffraction patterns present peaks at the same position in 2θ (bottom panes in Fig. 9a). Given the similarities in the lattices of CdTe and InSb, any solubility issues are difficult to detect through X-ray diffraction measurements. However, the differences in the Raman frequencies of the optical modes of these two compounds are large enough to identify readily the existence of possible InSb aggregates.



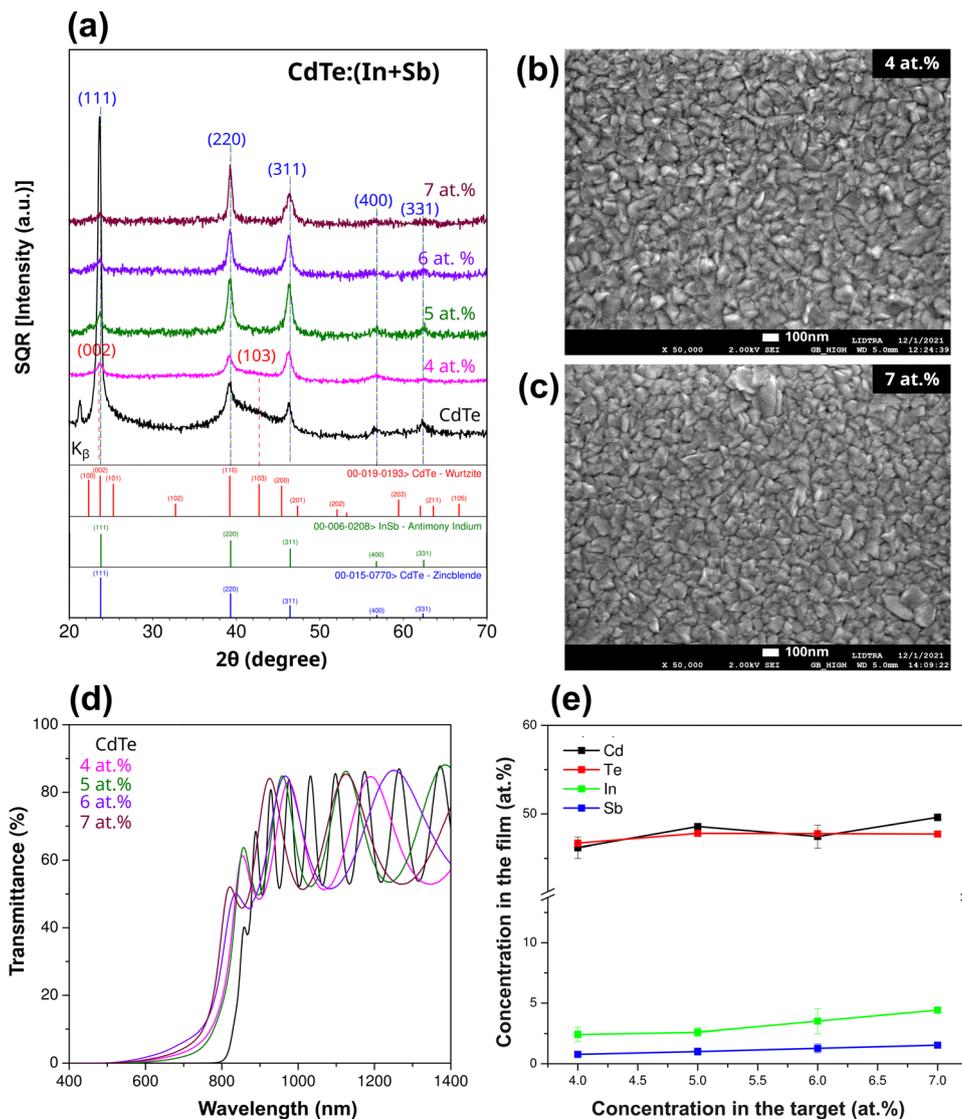


Fig. 9 (a) X-ray diffraction patterns of the CdTe:(In + Sb) films for the indicated codopant concentrations. (b) and (c) SEM surface micrographs of the samples with 4 and 7 at.% InSb, respectively; the white bar corresponds to 100 nm. (d) Vis-NIR spectra of the codoped films in the 400–1400 nm range. (e) Chemical composition of the CdTe:(In + Sb) films obtained using WDS as a function of the concentration of InSb in the sputtering target.

The frequencies of the longitudinal optical (LO) and transverse optical (TO) modes of CdTe are 139 and 167 cm^{-1} , respectively,⁶⁴ while those of InSb are 180 and 191 cm^{-1} .⁶⁵ In addition to the spectrum of CdTe, the Raman spectra of the codoped films exhibited the TO mode of InSb (Fig. S3a, ESI[†]). This result can be interpreted in two ways: either the adjacent codopant In + Sb has unsolvable solubility issues in CdTe, or the growth temperature was not appropriate for the complete incorporation of In and Sb in the lattice of CdTe. To investigate this matter further, the films were grown at higher substrate temperatures. It was found that when $T_s = 400$ °C, any signature of InSb in the Raman spectrum of CdTe:(In + Sb) vanished even for the films with the largest concentration of In + Sb in this work (7 at.%) (Fig. S3b, ESI[†]). At lower substrate temperatures, the TO mode of InSb was still observable. This result implies that important thermodynamic differences exist during the

growth of CdTe:(Ag + I) and CdTe:(In + Sb) and that a single set of growth parameters cannot be generalized for the same host. A possible reason for this result might be the differences in the types of chemical bonds involved in the atomic substitutions. Therefore, in CdTe:(Ag + I), the substitutions $\text{Ag} \rightarrow \text{Cd}$ and $\text{I} \rightarrow \text{Te}$ conserve the type of valence electrons of the host since silver and cadmium are both d-block elements. Analogously, both iodine and tellurium belong to the p-block. In CdTe:(In + Sb), however, the substitution $\text{In} \rightarrow \text{Cd}$ implies the substitution of a p-block element (In) for a d-block atom (Cd). Thus, each system host + codopants shall have its thermodynamical and chemical characteristics. In the growth of films, the pressure and substrate temperature determine the thermodynamical conditions of the process (out of equilibrium in the case of sputtering). The chemical characteristics and concentration of the impurities influence which compounds and



phases form under the existing conditions (pressure and temperature) during growth.

Contrary to the case of CdTe:(Ag + I), the electrical conductivity of CdTe:(In + Sb) did not improve. Indeed, the resistivity of the CdTe:(In + Sb) films was large for all codopant concentrations beyond the measurement capabilities of the employed Hall-effect system ($\sim 10^7 \Omega \text{ cm}$). Such large resistivities can be associated with the small grain size and large density of defects in these samples, as observed in the SEM images (Fig. 9b, c and Fig. S3c, d, ESI[†]). The average grain size in CdTe:(In + Sb) was reduced roughly 2.5 times with respect to that of undoped CdTe (~ 120 vs. 300 nm). These results show that neither In nor Sb produces recrystallization and defect passivation as halides do in CdTe. In the Vis-NIR spectra shown in Fig. 9d, it can be observed that the abruptness of the optical transmittance edge was maintained in the codoped films and that the average transmittance for energies below the band gap was around 70%, as in the case of undoped CdTe films. Fig. 9e shows the chemical composition of the films obtained by WDS. Indium incorporated more readily than Sb, while the concentrations of Cd and Te were nearly the same.

2.2 Terahertz spectroscopy

The results presented above show that for the substrate temperature of 275 °C, the electrical conductivity of CdTe was improved by five orders of magnitude if the adjacent codopants Ag + I were incorporated. Nonetheless, when the other pair of adjacent codopants In + Sb was used, the resistivity of the films remained high. In CdTe:(Ag + I), the photocurrent was largest when the concentration of adjacent codopants was 5 at%. This concentration was selected for further studies on the physical differences between CdTe:(Ag + I) and CdTe:(In + Sb). To this

end, electronic levels inside the band gap were probed through attenuated total reflectance spectroscopy (ATR) using a Fourier-transformed terahertz spectrometer. Fig. 10 shows the absorbance spectra of CdTe, CdTe:(Ag + I)-5% and CdTe:(In + Sb)-5%. In the wavenumber region between 70 and 280 cm^{-1} (Fig. 10a), the spectra of the three samples exhibited the TO and LO modes of CdTe at 142 and 169 cm^{-1} , respectively.

The ATR spectra ranging from 0.25 to 0.98 eV are shown in Fig. 10b. It is observed that the spectrum of pristine CdTe did not present absorption bands in this interval. The small features labeled with asterisks in the three spectra are residues from the subtraction of the substrate (glass) spectrum. The spectrum of CdTe:(Ag + I)-5% was strikingly different since two broad, well-defined absorbance bands developed with their maxima at 0.36 eV (S_d) and 0.66 eV (S_a). Furthermore, three weak features L_1 (0.49 eV), L_2 (0.52 eV) and L_3 (0.86 eV) were evident. Free carrier absorption has been reported in CdTe bulk and films,^{66–69} where, depending on the free carrier concentrations, the onset of the absorption occurred at wavelengths between 1.4 and 2.8 μm (0.44–0.88 eV). The onset of the free carrier absorption (fca), the blue dashed line depicted in Fig. 10b, occurred at 0.54 eV. A discussion of possible energy diagrams compatible with the ATR spectrum of CdTe:(Ag + I)-5% is presented in the ESI[†] (Fig. S4 and S5). From that analysis, the energy diagram shown in Fig. 11 is proposed to describe the electronic transitions observed in the absorbance spectrum of CdTe:(Ag + I)-5% illustrated in Fig. 10b.

2.3 Donor/acceptor sub-bands and intermediate band solar cells

In the diagram in Fig. 11, the position of the Fermi level (E_F) near the bottom of the donor sub-band S_d implies that most of

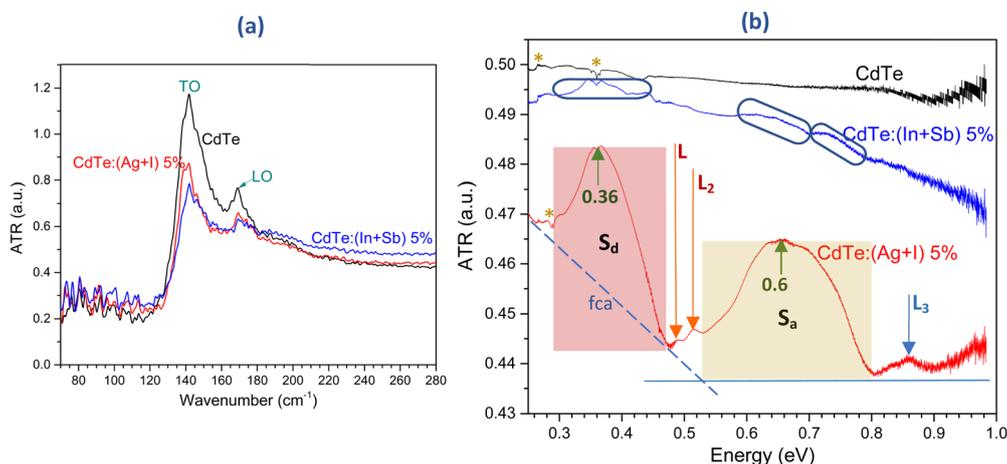


Fig. 10 Room temperature attenuated total reflection (ATR) terahertz spectroscopy absorbance measurements of CdTe, CdTe:(Ag + I)-5% and CdTe:(In + Sb)-5% films. (a) Transverse optical (TO) and longitudinal optical (LO) phonons of CdTe are observed at 142 and 169 cm^{-1} , respectively. (b) ATR spectra from 0.25 eV (2000 cm^{-1}) to 0.98 eV (7900 cm^{-1}). The spectrum of undoped CdTe did not present any clear absorption features. The spectrum of CdTe:(In + Sb) showed weak bands, denoted by the blue elongated shapes. Two well-defined absorption bands centered at 0.36 eV (S_d) and 0.66 eV (S_a) appeared in the spectrum of CdTe:(Ag + I). The widths of these bands were different (highlighted in the figure). The absorption due to free carriers is indicated by the blue dashed line labeled as fca. The appearance of the bands S_d and S_a correlated with the lower resistivity of the CdTe:(Ag + I)-5% films (750 $\Omega \text{ cm}$, Fig. 7a). The samples of CdTe and CdTe:(In + Sb)-5% were highly resistive ($\rho > 10^7 \Omega \text{ cm}$). The small sharp features in the spectra (denoted with asterisks) are remnants of the subtraction of the substrate signal.



films grown at 400 °C, even though it was the temperature at which In and Sb were incorporated completely into the CdTe lattice according to the Raman spectroscopy data depicted in Fig. S3b (ESI[†]). However, in the CdTe:(Ag + I) films, defect passivation through recrystallization played a role in their noted electrical and photoelectronic properties in analogy to the effects of treatments with chlorine.

2.4 Adjacent compensated codoping applied to CdS:(Ag + Cl)

To investigate further the applicability of ACC, cadmium sulfide films were grown by incorporating the adjacent codopants chlorine and silver. CdS is a II–VI semiconductor widely employed as a window or buffer layer in solar cell technologies, such as those based on CdTe, CuInSe₂, Cu₂ZnSnS₄, and hybrid perovskites. Besides analyzing the structural, electronic, lattice dynamics and optical properties of codoped CdS, this material was selected to investigate the effect of adjacent codopants in its intrinsic photoconductivity since CdS is a well-known photoconductor.^{70–72} It is shown below that, indeed, ACC improves this capacity of CdS.

CdS thin films were deposited on glass substrates at 250 °C. In this case, the selected adjacent codopants were silver and chlorine, as illustrated in Fig. 12. Silver chloride (AgCl) was used as the source of these elements in the fabrication of the sputtering targets. Other possible adjacent codopants for CdS are In + P, for which the compound InP is the natural source. However, preference was given to AgCl because of its lower cost. Films of CdS:(Ag + Cl) were grown with the following AgCl concentrations in the targets: 0.5, 1.0, 2.0, 3.0, 4.0 and 5 at%. These concentrations refer to the [Ag]/[Cd] ratios. The thicknesses of the samples varied between 76 and 110 nm (Table S3, ESI[†]).

Fig. 13a shows the X-ray diffraction patterns of the codoped films and pristine CdS. Only the undoped film presented a mixture of cubic and hexagonal phases. In the codoped samples, the crystalline structure was hexagonal (wurtzite type), as identified by the powder reference card PDF#00-006-0314.

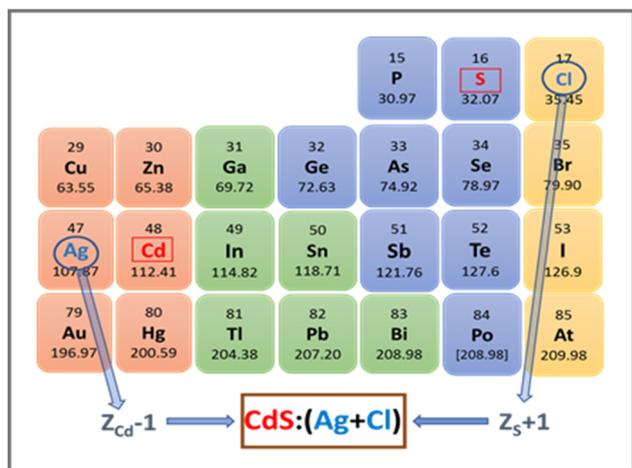


Fig. 12 Portion of the periodic table illustrating chlorine and silver as adjacent compensated codopants for cadmium sulfide (CdS). To incorporate these elements into CdS, silver chloride (AgCl) powder was used in the fabrication of the sputtering targets.

Diffraction peaks different from those of CdS were absent for codopant concentrations lower than 4 at%. In the patterns of the films with 4 and 5 at% AgCl, a small peak at 38° was identified as being related to Ag aggregates. It is not ruled out, however, that a complete incorporation of silver into the CdS lattice can be obtained at higher substrate temperatures, as occurred in the case of InSb and CdTe (see above).

The lattice parameter c of the hexagonal structure was determined from the X-ray diffractograms through Rietveld refinements using Fullprof.⁴³ The values of this parameter for undoped CdS and codoped CdS:(Ag + Cl) films are shown in Fig. S7a (ESI[†]) for the different concentrations of adjacent codopants. The strain ($S = \Delta c/c_0$, where c_0 is the lattice constant of the undoped film) induced by Ag + Cl was determined, which is lower than 0.2% for all films. Analogously, the change in the c/b ratio was lower than 0.5% (Fig. S7b, ESI[†]). The interatomic distances of CdS were hardly modified by the adjacent compensated codopants. The ionic radii of the Cd²⁺ and Ag¹⁺ cations for coordination four are 78 and 100 pm, respectively. The radii of four-fold coordinated anions S²⁻ and Cl¹⁻ are not known; however, as mentioned above, it is expected that their values maintain approximately the similarity that these elements exhibit for six-fold coordination, whose radii are 184 and 181 pm, respectively.⁴² Fig. 13b illustrates the room temperature Raman spectra of the films. Owing to the similar atomic masses of silver and chlorine with respect to cadmium and sulfur, respectively, the frequency and shape of the CdS Raman modes were basically unaltered. The transmittance spectra of the films are presented in Fig. 13c. It is noticed that the absorption edge is more abrupt for the 3 at% Ag + Cl film, indicating a lower number of defect levels close to the band edges. Accordingly, this sample presented the best photoconductivity performance (see below). The band gap was estimated from Tauc's plots. It varied monotonically with codopant concentration from 2.36 eV for undoped CdS to 2.18 eV for the film with 4 at% AgCl (Fig. S8, ESI[†]). Fig. 13d shows the chemical composition of the films obtained by WDS as a function of the nominal concentration of AgCl in the sputtering targets. The concentrations of Ag and Cl in the targets were replicated closely in the films. The contents of S and Cd decreased correspondingly when the dopant concentration rose.

Room temperature Hall effect measurements were carried out using silver for the contacts (Fig. 14a). In general, the incorporation of Ag + Cl improved the electrical properties of CdS, whose n-type characteristics remained unchanged. The resistivity decreased from 8.2×10^6 for CdS to 163 Ω cm for the CdS:(Ag + Cl)-4% film, that is, a reduction of four orders of magnitude. The free charge carrier density increased from 2×10^{14} in CdS up to 7×10^{16} cm⁻³ for the sample with 3 at% AgCl. The average mobility of the film with 0.5 at% Ag + Cl was 6.7 cm² V⁻¹ s⁻¹, an enhancement of three orders of magnitude with respect to that of undoped CdS, which had a value of 0.005 cm² V⁻¹ s⁻¹. The electrical parameters of the film with 5 at% Ag + Cl could not be obtained reliably owing to contact issues.

CdS is a well-known photoconductor.^{69–71} It was considered convenient to test the effect of ACC on this natural property of CdS. The photosensitivity ($r = I_{\text{Light}}/I_{\text{Dark}}$) of all the samples is



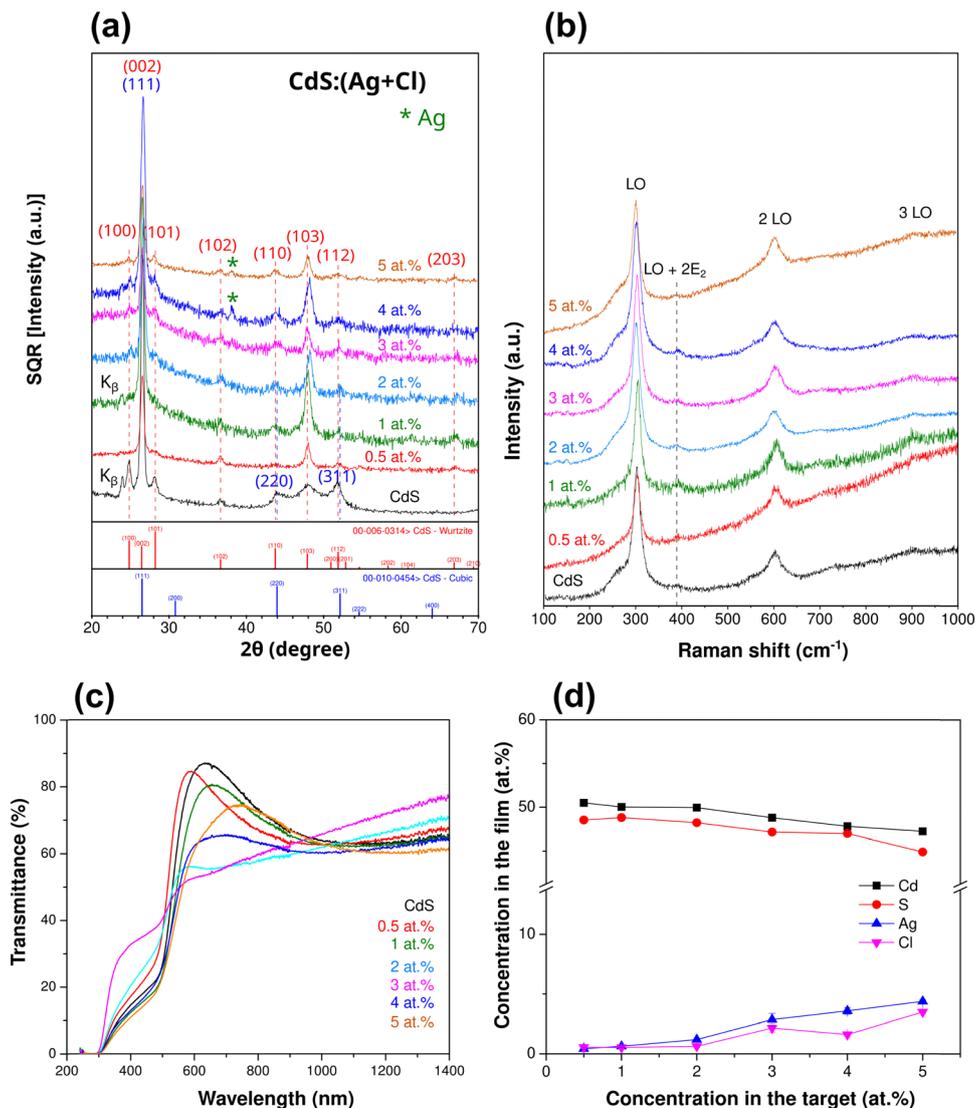


Fig. 13 (a) X-ray diffraction patterns of the CdS and CdS:(Ag + Cl) films. As a reference, the powder diffraction cards for CdS illustrating hexagonal (PDF#00-006-0314) and cubic (PDF#00-010-0454) symmetry are shown at the bottom. (b) Room temperature Raman spectra of undoped and codoped films. (c) UV-Vis-NIR transmittance spectra. (d) Chemical composition of the sputtered films obtained using WDS as a function of the nominal concentration of AgCl in the sputtering target.

presented in Fig. 14b. For undoped CdS, the photocurrent was four times larger than in the dark ($r = 4$). Adjacent codopants improved this value since the photosensitivity of all the codoped films was larger than 4. Interestingly, the photosensitivity of the film with 3 at% was $r = 115$. Fig. 14c shows the photocurrent of this film for applied voltages between -10 and $+10$ V.

In summary, ACC applied to CdS produced films whose crystalline structure, optical properties and lattice dynamics were affected paltry. The electrical resistivity was reduced by four orders of magnitude, with significant improvements in the free carrier density and mobility. The photosensitivity of CdS was enhanced for all codopant concentrations. The largest improvement ($\sim 10^2$) was obtained for the film with 3 at%. The enhancement of the photoconductivity in CdS presents some analogy with studies of CdTe/CdS solar cells, in which it

was found that chlorine decorates CdS grain boundaries and lowers the defect density by promoting recrystallization.⁷³

In the case of CdTe:(Ag + I), the largest photosensitivity was obtained for the films with 5 at% Ag + I. The existence of optimal concentrations of adjacent codopants in the photoconductivity of CdTe and CdS is noteworthy. The reproducibility of these results was verified by measuring the photosensitivity in samples grown with the same parameters in different runs. The incorporation of impurities in the host lattice occurs at random sites. However, the existence of reproducible concentrations, which optimize the photoconductivity, is consistent with spatial distributions of the adjacent codopants, not totally arbitrary. The results indicate that the average distribution of codopants was replicated in the samples. The driving mechanism behind this behavior might be the energy reduction of the host + codopant system. A hypothetical



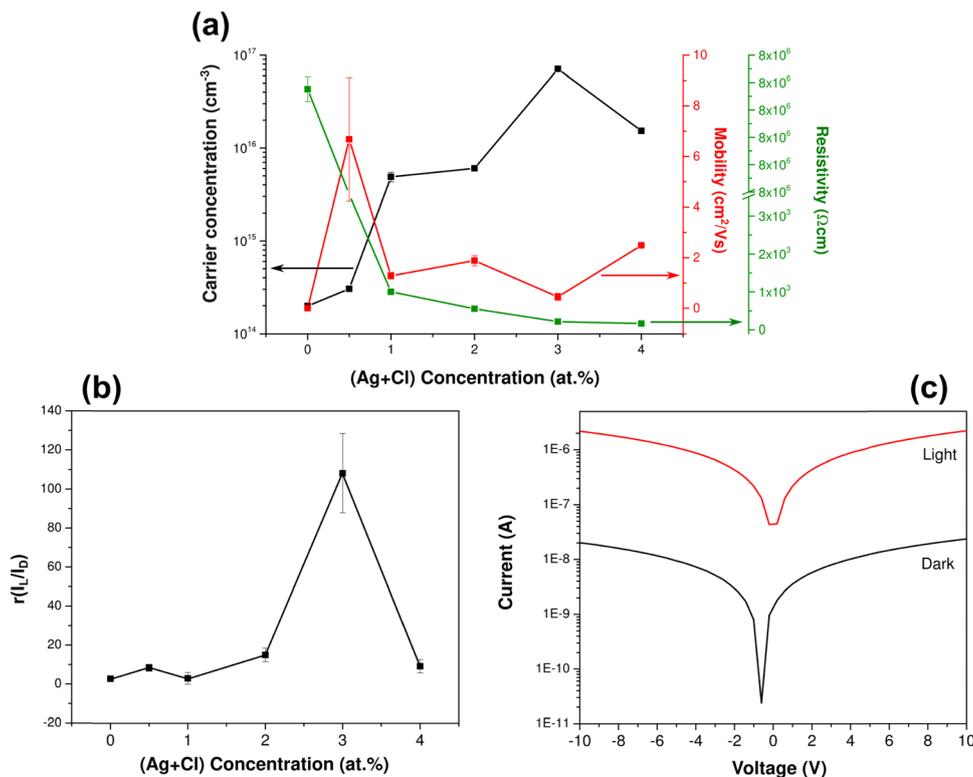


Fig. 14 (a) Room temperature electrical parameters of CdS and CdS:(Ag + Cl) films obtained through Hall effect measurements as a function of the concentration of adjacent codopants. (b) Photosensitivity ($r = I_{\text{Light}}/I_{\text{Dark}}$) of the films. (c) Comparison of the photocurrent and current in the dark as a function of the applied voltage for the film with 3 at% AgCl. The photocurrent was two orders of magnitude larger than the one in the dark.

distribution of impurities could simply be an optimal average inter-impurity distance or a more elaborate distribution that could involve codopants, vacancies, or complexes. In either case, the physical phenomena involved in the optimization modulate the photo generation, the transport of the excited electron/hole pairs, and the competing recombination processes. Further studies are required to shed light on the underlying mechanisms of photoconductivity in CdTe and CdS and their dependence on the concentration and spatial distribution of the adjacent codopants. In addition, given the striking differences in results depending on the use of halide co-dopants (I for CdTe and Cl for CdS), further work is required to evaluate the impact of halide inclusion on the properties of the codoped materials, which may have effects analogous to chlorine treatments in CdTe device processing. In this direction, films of CdTe:I-5 at% were deposited at 275 °C (the same concentration and substrate temperature used to grow the best performing CdTe:(Ag + I) films), obtaining highly resistive polycrystalline films (Fig. S9a, ESI†). This indicates that the conductivity of the codoped films results from the combined effect of the adjacent codopants Ag + I. Detailed analyses of the CdTe:I and CdS:Cl systems, varying growth conditions and halide concentrations are necessary to shine light on the role of halides in the codoped films.

2.5 Sub-bands: some possible scenarios

The energy of the acceptor and donor sub-bands relative to the host's conduction and valence band edges strongly influences

the electrical and optoelectronic properties of the codoped semiconductors. In the discussion below, a two-sub-band model, as observed in CdTe:(Ag + I) 5 at%, is considered to analyze possible scenarios of the changes introduced by adjacent codopants in the band structure of the host. The formation of more than two sub-bands in different host + codopant systems is not ruled out. However, the consideration of two sub-bands, a donor-like and an acceptor-like, is a natural base for the analysis of more complicated distributions of the impurity levels. Sub-bands S_d and S_a may present different ionization energies (E_n , E_p), widths (δE_n , δE_p) and densities of states (D_n , D_p). A good number of combinations can occur when the ACC paradigm is applied to different semiconductors. For example, in one particular material with different pairs of codopants, or for the same host + codopants system grown under different thermodynamical conditions or deposition method.

Given the experimental data for CdTe:(Ag + I) gathered so far, the energy diagram depicted in Fig. 11 was devised, indicating not only the existence of the sub-bands S_d and S_a but also of some shallow levels detected by photoluminescence (Fig. 6c) and temperature-dependent Hall effect measurements (Fig. S6, ESI†). Silver and iodine, separately, do not form deep levels in CdTe. The former has an ionization energy of 0.15 eV, while the latter is 0.05 eV.²⁹ The origin of the change from shallow levels to the formation of deep sub-bands, as found in this work, needs to be determined. In what follows, the properties of the sub-bands (E_n , E_p , δE_n and δE_p) and their effect on



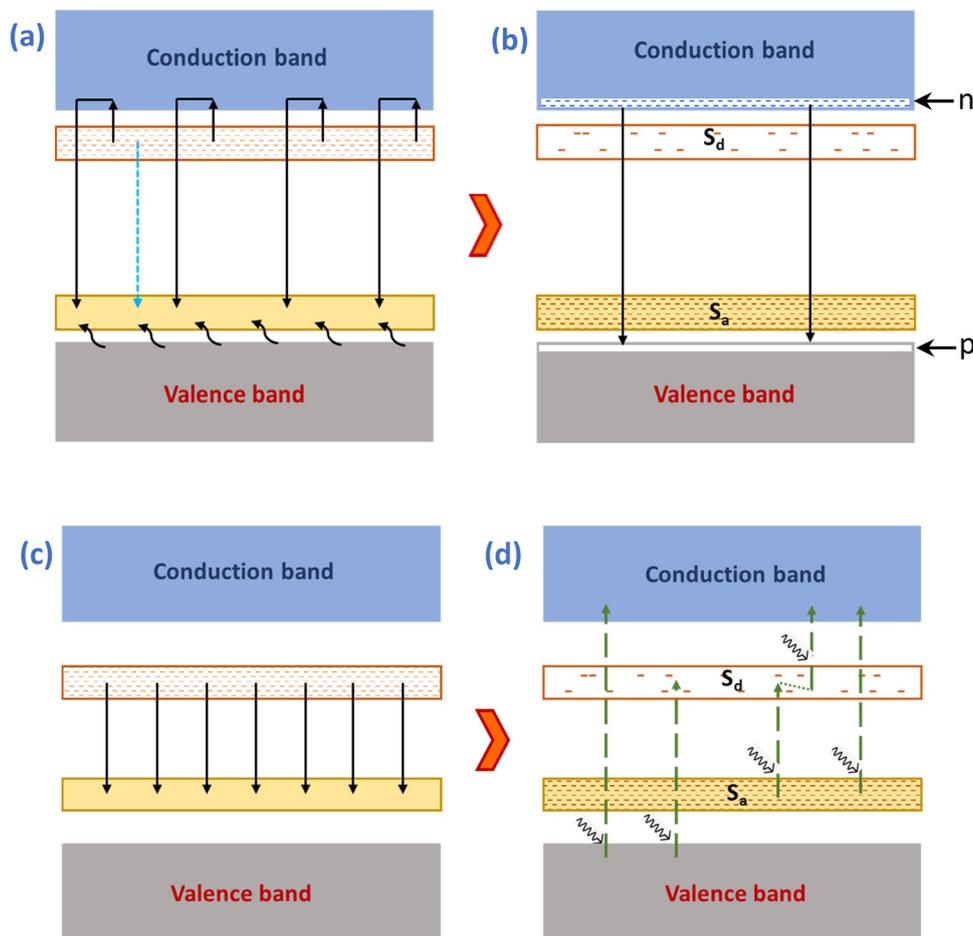


Fig. 15 Energy diagrams for two sub-bands in the band gap: a donor-like (S_d) and an acceptor-like (S_a) with widths $\delta E_n \approx \delta E_p$. (a) Shallow sub-bands. Electrons from S_d can transfer to the CB, followed by transitions to S_a . Thermal excitations and quantum tunneling may promote electrons from the VB to S_a . Electron-hole recombinations $S_d \rightarrow S_a$ are indicated by the blue dashed arrow. (b) Once S_a is occupied, band-to-band recombination of electrons in the CB (with density n) with holes in the VB (with density p) produces low conductivity for $n \approx p$. (c) If the sub-bands are deep, transitions from the VB to S_a and from S_d to the CB are negligible. Electrons in S_d lower their energy by recombining with states in S_a . (d) If the densities of states of the donor and acceptor sub-bands are comparable, most states in S_a will be occupied and those in S_d will be mostly vacant. Statistical fluctuations prevent completely full or empty sub-bands. The green dashed arrows indicate transitions of electrons under illumination for photons with energies $E_i \approx E_g$. The dotted green line indicates the relaxation processes through the emission of phonons.

the charge transport processes through direct electronic transitions involving S_d and S_a are discussed. Other mechanisms, such as trapping–detrapping or Auger recombination, are not considered herein. When two sub-bands, S_d and S_a , form, a lower energy state of the crystal is attained when the electrons from the donor atoms occupy the lower energy states in the acceptor sub-band. Physically, this means that the electrons from the donors move around through the lattice until they eventually fill the incomplete bonds of the acceptor atoms.

As a starting point in this analysis, the case when $\delta E_n \approx \delta E_p$ (similar sub-band widths) is considered. Sub-bands S_d and S_a can be shallow or deep. If the sub-bands are shallow (Fig. 15a), electrons from S_d may access the CB through thermal excitations or quantum tunneling and travel amidst the crystal until recombine with holes in S_a . Analogously, electrons from the VB can transfer to S_a . Both processes may occur until all states in S_a are occupied. Then, additional electronic transitions towards the full sub-band S_a cannot occur, and owing to statistical

fluctuations, a low concentration of electrons (n) in the CB and holes (p) in the VB remains (Fig. 15b). If $p \approx n$, (nearly) full compensation is obtained owing to band-to-band recombination (black arrows in Fig. 15b). The depleted sub-band S_d could be utilized for electron transport if contacts with appropriate work function were applied.

If the ionization energies for S_d and S_a are large (deep bands), as shown in Fig. 15c, electrons from S_d cannot be thermally excited or tunneled to the CB, or from the VB to S_a . Electrons in S_d lower their energy by recombining with the available states in S_a . This process may continue until S_d is depleted, and the states in S_a are occupied (Fig. 15d). In this situation, several transitions are possible if the material is exposed to a photon flux with energies $\approx E_g$, as indicated by the green dashed arrows illustrated in Fig. 15d.

Next, the case of deep sub-bands when $\delta E_n \neq \delta E_p$ is considered. If $\delta E_n < \delta E_p$ (Fig. 16a), S_a is partially filled, and S_d is depleted. Accessible states in S_a , S_d and the CB can be used



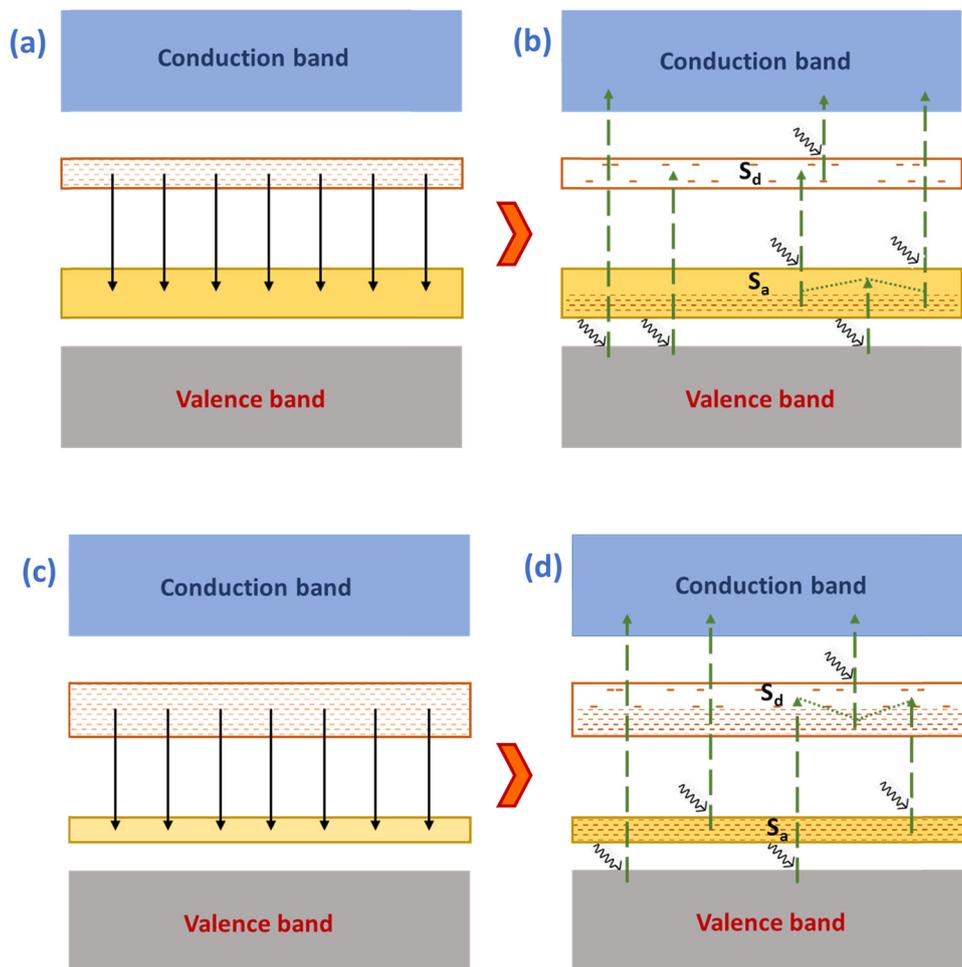


Fig. 16 Two possible energy diagrams for the deep donor (S_d) and acceptor (S_a) sub-bands with different widths $\delta E_n \neq \delta E_p$. (a) If $\delta E_n < \delta E_p$, electrons in S_d lower their energy via transitions to S_a . (b) S_a is not fully occupied, while S_d is depleted. (c) If $\delta E_n > \delta E_p$, electrons in S_d lower their energy through transitions to S_a . (d) If the number of electrons in S_d is larger than the available states in S_a , the former will be partially empty, and the latter will be occupied. The green dashed arrows indicate transitions of electrons under illumination with incident photons, with energies $E_i \approx E_g$. The dotted green lines indicate the relaxation processes through the emission of phonons.

for the arrival of photo-excited electrons from S_a or VB, as illustrated by the green dashed arrows in Fig. 16b. The dotted green lines indicate possible relaxation processes through the emission of phonons. If $\delta E_n > \delta E_p$ (Fig. 16c), available states for photoexcited electrons occur in the CB and partially in S_d . The generation of free carriers under illumination is largely assisted when the sub-bands are deep, especially if $\delta E_n < \delta E_p$ (Fig. 16a and b) (more pathways for electronic transitions).

The energy diagrams illustrated in Fig. 15 and 16 describe the distribution of carriers relevant to the electrical and photo-electronic properties of a semiconductor, providing sub-bands S_d and S_a form. The diagram illustrated in Fig. 11 for CdTe:(Ag + I) corresponds to the type depicted in Fig. 16b. In different materials, a different distribution of acceptor and donor levels may occur depending on the type and concentration of codopants and on the thermodynamical conditions during growth. Other combinations of adjacent codopants need to be explored. For instance, those using uncompensated p-p ($Z_A - 1, Z_B - 1$ in compound AB) or n-n ($Z_A + 1, Z_B + 1$) codopants. These cases

may have lower solubility than the compensated ones because of the strain that is produced because two types of impurities, both with smaller (p-p) or larger (n-n) radii, are allocated in the host's lattice. The fact, however, of being adjacent helps to keep the lattice strain low. In the case of multielement compounds, the ACC approach can also be applied. For instance, in ternary compounds $A_xB_yR_q$ with cations A, B and anions R (as in perovskites, chalcopyrites, or delafossites), several combinations can be achieved, such as $Z_A \pm i$ with $Z_R \pm j$, $i, j = 1, 2$; or $Z_B \pm i$ with $Z_R \pm j$, $i, j = 1, 2$; or $Z_A \pm i$ with $Z_B \pm j$, $i, j = 1, 2$.

Preliminary results on other semiconductors where ACC was applied, such as Ge:(Ga + As), CdSe:(Ag + Br), CdSe:(In + As), ZnO:(Ga + N), ZnO:(Cu + F) and the 2D layered compound WS_2 :(Hf + Cl), showed that adjacent codopants can improve the host electrical conductivity with no issues in solubility. It is noticed that in WS_2 :(Hf + Cl), a different combination of adjacent codopants was employed in the sense that hafnium is the second nearest neighbor to tungsten, while chlorine is the nearest neighbor to sulphur in the periodic table.



3. Conclusions and remarks

Adjacent compensated codoping (alloying) is introduced as an alternative approach to modify the electrical and optoelectronic properties of semiconductors. Owing to its characteristics, ACC is expected to produce excellent solubilities of the codopants and low lattice strain in the hosts, which is consistent with the results of this work. Moreover, the incorporation of soluble adjacent codopants produces slight modifications to lattice dynamics. However, the electrical and photoelectronic properties of the host can be modified to a large extent. Each codoped material is a particular thermodynamic system that requires optimization of the growth conditions and dopant concentrations. In the examples presented herein, it was found that electrical conductivity or photoconductivity was best for some specific codopant concentrations. One exception, however, was found: CdTe:(In + Sb) whose large resistivity did not decrease for the growth conditions and concentrations of dopants used in this work. However, aggregates of Ag₂Te and Ag usually found in CdTe:Ag were no longer detected in the corresponding ACC compound CdTe:(Ag + I), highlighting the potential of ACC for increasing solubility limits. For CdTe:(Ag + I) and CdS:(Ag + Cl), the largest photosensitivity ($r = I_{\text{Light}}/I_{\text{Dark}}$) was obtained when the codopant concentrations were 5 ($r = 5.15 \times 10^3$) and 3 at% ($r = 1.15 \times 10^2$), respectively. For these concentrations, the lifetimes of the carriers were sufficiently large enough to produce large photocurrents, which were nonexistent in the undoped materials. Adjacent codopants passivated the recombination centers, increasing the lifetimes of the carriers, which is reminiscent of the effect of chlorine in CdTe.⁷³ In our case, the sole incorporation of iodine in sputtered CdTe:I with 5 at% iodine yielded highly resistive films. This indicates that in CdTe:(Ag + I), a synergy between the silver and iodine atoms occurs, playing an important role in the charge transport properties of codoped CdTe.

An important result in CdTe:(Ag + I) was the formation of deep sub-bands in the band gap. In particular, deep sub-bands can be used for multi-step transitions of electrons to the conduction band through excitations with photons with energies lower than E_g , as has been conceptualized in intermediate-band photovoltaics. ACC can be applied to other gapped materials, such as insulators. In these cases, sub-band engineering can be performed to modify the optical absorption or the photoelectronic response aimed at specific functionalities.

The analyses of the materials presented in this work were not extensive. Additional work needs to be performed on several aspects of ACC to investigate the effects of adjacent codopants on the properties of the hosts. Among these, the necessary theoretical framework to determine ionization energies, the number and distribution of donor and acceptor sub-bands, and the statistical fluctuations in the spatial distribution of the codopants in the host stand out. Another future extension of this work concerns the study of bulk crystals and films using other deposition techniques since different in- or out-of-equilibrium conditions may yield different electronic and photoelectronic properties. Studies are needed on individually iodine-doped CdTe and/or chlorine-doped CdS to

separate the properties that arise from ACC from the properties that are specific to the halide doping of cadmium-based semiconductors.

Fermi level pinning has been a bottleneck in the development and application of different types of materials. Whether ACC can address this problem remains to be investigated. In particular, quantum materials have doping issues of one type or another, as pointed out by Zunger and Malyi.⁷⁴ In their analysis, the following materials were identified as being limited by the lack of control over the Fermi level position: superconductors, topological insulators, organic semiconductors, conducting oxides, hybrid perovskites, quantum spin liquids and half-Heusler A^{III}B^XC^V alloys.

Future work will determine the extent to which ACC may become a pathway to move forward with doping capabilities in semiconductor science and technology. Finally, Richard Feynman's statement on nanotechnology is paraphrased: there is plenty of room in the band gap.

4. Methods

All the samples used in this work were prepared as thin films deposited by radio frequency sputtering on previously cleaned glass substrates (Corning glass 2947 slides, 75 × 25 mm²). Initially, they were cleaned with Dextran and rinsed with water. Subsequently, the slides were submerged in a chromic acid cleaning solution for 24 hours. Afterwards, they were rinsed with distilled water and placed in a 3 : 1 HNO₃-distilled water solution, which was boiled on a hot plate for 3 hours. Finally, the slides were rinsed with distilled water and stored in clean ethanol for future use. The substrates were dried with a flux of nitrogen before being placed in the vacuum chamber. The targets (2" diameter and 1/8" thickness) were made by cold pressing a mixture of powders of the host and codopants in a stainless-steel mold. The base pressure in all growths was ~10⁻⁶ Torr. Details of the compositions of the targets and deposition parameters are presented in Table 1. Before initiating the film deposition, the targets were pre-sputtered for 5 minutes to eliminate surface contaminants. The target-substrate distance was 8.5 cm.

The X-ray diffraction measurements of the films were carried out at a grazing angle of 4° using a Rigaku D/Max-2100 diffractometer with a Cu k_α line ($\lambda = 1.5406$ Å). Inelastic light scattering and photoluminescence experiments were obtained using an HR Evolution Horiba micro-Raman spectrometer by employing a diffraction grating of 1800 grove mm⁻¹. All CdTe films (undoped and codoped) were excited with a 785 nm diode laser for the Raman measurements and with a 632.8 nm He-Ne laser for the PL measurements. Raman experiments in CdS films were obtained using the 488.0 nm line of an Ar⁺ laser. The chemical composition of the samples was determined by wavelength-dispersive spectroscopy (WDS) using a Philips ESEM scanning electron microscope (XL30). The electrical properties (resistivity, carrier concentration and mobility) were measured in van der Paw configuration in an Ecopia HMS5000



Table 1 Deposition parameters for sputtered films

Host (purity)	Adjacent codopants source (purity) and concentrations (at%) used in this work	Substrate temperature (°C)	Radio frequency power (W)	Argon partial pressure (mTorr)	Deposition time (minutes)
CdTe (99.999%)	AgI (99.9%) 0.5, 1.0, 3.0, 4.0, 5.0, 6.0, 7.0 InSb (99.99%) 4.0, 5.0, 6.0, 7.0	275	35	1.0	30
		275			
		400			
CdS (99.999%)	AgCl (99.9%) 0.5, 1.0, 2.0, 3.0, 4.0, 5.0	250	40	4.0	30

Hall Effect system. The optical transmission spectra were obtained at normal incidence in a Film-Tek spectrophotometer model TM-3000. For the photoconductivity experiments, a halogen lamp was calibrated with a silicon reference cell (model 91150V by Oriel Instruments) at a power density of 100 mW cm⁻² on the sample surface. The current developed by the sample under an applied voltage was detected using a Keithley 2401 source meter. The attenuated total reflection (ATR) terahertz spectroscopy measurements were carried out at room temperature using a Fourier transform infrared spectrometer, Bruker Vertex 70v, at a pressure below 2.00 μPa to avoid absorption from atmospheric water vapor and CO₂. A mercury lamp was used as a broadband far-infrared source in conjunction with a room-temperature RT-DTGS detector. The mid-infrared region was investigated with a MIR source, MIR-FIR beam splitter and detector (Bruker FM). The ATR spectra were obtained at a fixed angle of incidence $\theta = 45^\circ$ using a diamond prism with a top square surface area of 4 mm² (Bruker Platinum ATR Unit A225), averaging 150 scans at a 2.5 kHz scan velocity.

Data availability

The data supporting this article are included in the ESI.†

Conflicts of interest

There are no conflicts of interest to declare.

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